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                WPINDEX/WPIDS/WPIX enhanced with ECLA and current
                 U.S. National Patent Classification
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                 IFICDB, IFIPAT, and IFIUDB enhanced with new custom
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                 spectra
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                 CA/CAplus and CASREACT patent number format for U.S.
                 applications updated
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                 EMBASE, EMBAL, and LEMBASE reloaded with enhancements
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                 STN AnaVist, Version 1, to be discontinued
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                 predefined hit display formats
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NEWS 22 APR 28
                 IMSRESEARCH reloaded with enhancements
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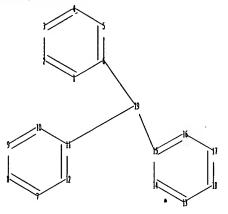
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chain nodes :

19

ring nodes :

1 2 3 4 5 6 7 8 9 10 11 12 13 14 15 16 17 18

chain bonds :

6-19 11-19 15-19

ring bonds :

1-2 1-6 2-3 3-4 4-5 5-6 7-8 7-12 8-9 9-10 10-11 11-12 13-14 13-18

14-15 15-16 16-17 17-18

exact/norm bonds :

6-19 11-19 15-19

normalized bonds :

1-2 1-6 2-3 3-4 4-5 5-6 7-8 7-12 8-9 9-10 10-11 11-12 13-14 13-18

14-15 15-16 16-17 17-18

Match level :

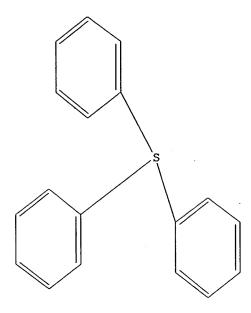
1:Atom 2:Atom 3:Atom 4:Atom 5:Atom 6:Atom 7:Atom 8:Atom 9:Atom 10:Atom 11:Atom 12:Atom 13:Atom 14:Atom 15:Atom 16:Atom 17:Atom 18:Atom 19:CLASS

L1 STRUCTURE UPLOADED

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L1 HAS NO ANSWERS

L1 STR



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=> S L1 FULL
FULL SEARCH INITIATED 09:55:45 FILE 'REGISTRY'
FULL SCREEN SEARCH COMPLETED - 5309 TO ITERATE

100.0% PROCESSED 5309 ITERATIONS

4378 ANSWERS

SEARCH TIME: 00.00.01

L2 4378 SEA SSS FUL L1

=> FILE CAPLUS
COST IN U.S. DOLLARS

SINCE FILE TOTAL ENTRY SESSION 178.36 178.57

FULL ESTIMATED COST

FILE 'CAPLUS' ENTERED AT 09:55:53 ON 06 JUL 2008 USE IS SUBJECT TO THE TERMS OF YOUR STN CUSTOMER AGREEMENT. PLEASE SEE "HELP USAGETERMS" FOR DETAILS. COPYRIGHT (C) 2008 AMERICAN CHEMICAL SOCIETY (ACS)

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FILE COVERS 1907 - 6 Jul 2008 VOL 149 ISS 2

FILE LAST UPDATED: 4 Jul 2008 (20080704/ED)

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=> S L2

5740 L2 · L3

=> S L3 AND GRIGNARD

44887 GRIGNARD

31 L3 AND GRIGNARD L4

=> S L4 AND SULFOXIDE

40064 SULFOXIDE

18 L4 AND SULFOXIDE L5

=> D L5 IBIB ABS HITSTR 1-18

ANSWER 1 OF 18 CAPLUS COPYRIGHT 2008 ACS on STN

2006:214891 CAPLUS ACCESSION NUMBER:

DOCUMENT NUMBER:

145:198689

TITLE:

Synthesis of reactive chemical additives for

functional nanoimprinted polymer film

AUTHOR(S):

Koylu, Damla; Jhaveri, Sarav B.; Carter, Kenneth R. Polymer Science and Engineering Department, Conte

CORPORATE SOURCE: Center for Polymer Research, University of

Massachusetts - Amherst, Amherst, MA, 01003, USA

SOURCE:

Polymer Preprints (American Chemical Society, Division

of Polymer Chemistry) (2006), 47(1), 548

CODEN: ACPPAY; ISSN: 0032-3934

PUBLISHER: American Chemical Society, Division of Polymer

Chemistry

DOCUMENT TYPE:

Journal; (computer optical disk)

LANGUAGE:

English

Synthesized triphenylsulfonium salts were used for incorporation as additives in functional polymer films, particularly as a monomer and a photoacid generator. Sulfoxide functionality along with methacrylate (monomer) functionality were incorporated in the same mol. to obtain a photoacid monomer mol. 2H-pyran-3,4-dihydro(8CI,9CI) was used in order to protect the alc. group of 4-bromo benzyl alc. Grignard reaction was carried out on the alc. protected bromide followed by addition of phenylsulfoxide. Incorporation of the photoacid monomer within crosslinked films and nanostructures has the ability to produce films that can generate acid upon photolysis.

IT903515-14-0P

> RL: RCT (Reactant); SPN (Synthetic preparation); PREP (Preparation); RACT (Reactant or reagent)

(synthesis of reactive chemical additives for functional nanoimprinted polymer film)

903515-14-0 CAPLUS RN

Sulfonium, [4-(hydroxymethyl)phenyl]diphenyl-, bromide (1:1) (CA INDEX CN NAME)

● Br-

IT 903515-16-2P

RL: SPN (Synthetic preparation); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses)

(synthesis of reactive chemical additives for functional nanoimprinted polymer film)

RN 903515-16-2 CAPLUS

CN Sulfonium, [4-[[(2-methyl-1-oxo-2-propenyl)oxy]methyl]phenyl]diphenyl-, (OC-6-11)-hexafluoroantimonate(1-) (9CI) (CA INDEX NAME)

CM 1

CRN 903515-15-1 CMF C23 H21 O2 S

CM 2

CRN 17111-95-4 CMF F6 Sb CCI CCS

REFERENCE COUNT: 9 THERE ARE 9 CITED REFERENCES AVAILABLE FOR THIS RECORD. ALL CITATIONS AVAILABLE IN THE RE FORMAT

L5 ANSWER 2 OF 18 CAPLUS COPYRIGHT 2008 ACS on STN

ACCESSION NUMBER: 2005:371213 CAPLUS

DOCUMENT NUMBER: 142:411837

TITLE: Process for producing triarylsulfonium salt for resist

acid generator and cationic polymerization catalysts

INVENTOR(S): Sumino, Motoshige; Fukasawa, Kazuhito; Imazeki,

Shigeaki; Watanabe, Tetsuya

PATENT ASSIGNEE(S): Wako Pure Chemical Industries, Ltd., Japan

SOURCE: PCT Int. Appl., 48 pp.

CODEN: PIXXD2

DOCUMENT TYPE: Patent LANGUAGE: Japanese

FAMILY ACC. NUM. COUNT: 1

PATENT INFORMATION:

	PAT	CENT 1	.00			KIN)	DATE		4	AP.PL	ICAT:	I NO I	NO.		Di	ATE	
	WO 2005037778			A1	A1 20050428		WO 2004-JP14604				20041004							
		W:	ΑE,	AG,	AL,	AM,	AT,	AU,	ΑZ,	BA,	BB,	BG,	BR,	BW,	BY,	BZ,	CA,	CH,
			CN,	CO,	CR,	CU,	CZ,	DE,	DK,	DM,	DZ,	EC,	EE,	EG,	ES,	FI,	GB,	GD,
			GE,	GH,	GM,	HR,	HU,	ID,	IL,	IN,	IS,	JP,	KE,	KG,	KP,	KR,	ΚZ,	LC,
			LK,	LR,	LS,	LT,	LU,	LV,	MA,	MD,	MG,	MK,	MN,	MW,	MX,	MZ,	NA,	NI,
			NO,	NZ,	ÓΜ,	PG,	PH,	PL,	PT,	RO,	RU,	SC,	SD,	SE,	SG,	SK,	SL,	SY,
			ТJ,	TM,	TN,	TR,	TT,	TZ,	UA,	UG,	US,	UZ,	VC,	VN,	YU,	ZA,	ZM,	zw
		RW:	BW,	GH,	GM,	KE,	LS,	MW,	ΜZ,	NA,	SD,	SL,	SZ,	TZ,	UG,	ZM,	ZW,	AM,
			ΑZ,	BY,	KG,	ΚZ,	MD,	RU,	ТJ,	TM,	AT,	BE,	BG,	CH,	CY,	CZ,	DE,	DK,
			EE,	ES,	FI,	FR,	GB,	GR,	HU,	ΙE,	IT,	LU,	MC,	NL,	PL,	PT,	RO,	SE,
			SI,	SK,	TR,	BF,	ВJ,	CF,	CG,	CI,	CM,	GΑ,	GN,	GQ,	GW,	ML,	MR,	NE,
			SN,	TD,	TG													
	EP 1676835						EP 2004-792015				20041004							
		R:	AT,	BE,	CH,	DE,	DK,	ES,	FR,	GB,	GR,	IT,	LI,	LU,	ΝL,	SE,	MC,	PT,
			ΙE,	SI,	FI,	RO,	CY,	TR,	BG,	CZ,	EE,	HU,	PL,	SK				
	CN	1871	212			Α		2006	1129		CN 2	004-	8003	0948		2	0041	004
	US	2007	0083	060		A1	•	2007	0412		US 2	006-	5762	99	•	2	0060	419
PRIOR	PRIORITY APPLN. INFO.:									JP 2	003-	3607	74	7	A 2	0031	021	
											WO 2	004-	JP14	604	Ī	W 2	0041	004

OTHER SOURCE(S): MARPAT 142:411837

AB A triarylsulfonium salt in which only one aromatic ring differs from the others can be efficiently produced. The process, which is for producing a triarylsulfonium salt R(C6H4R1)2S+ Al- (wherein R represents aryl optionally having a substituent different from R1; and Al represents a strong-acid residue), is characterized by reacting a diaryl sulfoxide (C6H4R1)2SO with an aryl-Grignard reagent RMgX (wherein X represents halogen) in the presence of an activator having a high affinity for oxygen, the activator being used in an amount of 3 to 7.5 equiv to the diaryl sulfoxide, and then reacting the reaction product with either a strong acid represented by the general formula HA1 or a salt of the acid.

IT 4189-82-6P 347841-68-3P 475598-78-8P 475598-82-4P 753025-61-5P 753025-62-6P 753025-66-0P 753025-68-2P 753025-71-7P 753025-73-9P 753025-75-1P 753025-77-3P 753025-78-4P 753025-80-8P 753025-81-9P

850345-82-3P 850345-83-4P 850345-84-5P RL: CAT (Catalyst use); IMF (Industrial manufacture); PREP (Preparation);

USES (Uses)

(process for producing triarylsulfonium salt for resist acid generator and cationic polymerization catalysts)

RN 4189-82-6 CAPLUS

CN Sulfonium, (4-methylphenyl)diphenyl-, bromide (9CI) (CA INDEX NAME)

● Br

RN 347841-68-3 CAPLUS

CN Sulfonium, diphenyl(2,4,6-trimethylphenyl)-, bromide (1:1) (CA INDEX NAME)

$$\begin{array}{c|c} Me & Me \\ \hline & S \stackrel{+}{\longrightarrow} Ph \\ Me & Ph \end{array}$$

• Br

RN 475598-78-8 CAPLUS

CN Sulfonium, (4-fluorophenyl)diphenyl-, bromide (1:1) (CA INDEX NAME)

• Br

RN 475598-82-4 CAPLUS

CN Sulfonium, bis(4-fluorophenyl)phenyl-, bromide (1:1) (CA INDEX NAME)

07/06/200806/07/2008 Page 8

• Br-

RN 753025-61-5 CAPLUS CN Sulfonium, (2-methylphenyl)diphenyl-, bromide (1:1) (CA INDEX NAME)

• Br-

RN 753025-62-6 CAPLUS CN Sulfonium, (4-cyclohexylphenyl)diphenyl-, bromide (1:1) (CA INDEX NAME)

• Br-

RN 753025-66-0 CAPLUS CN Sulfonium, (3-methoxyphenyl)diphenyl-, bromide (1:1) (CA INDEX NAME)

● Br⁻

RN 753025-68-2 CAPLUS
CN Sulfonium, (4-butoxyphenyl)diphenyl-, bromide (1:1) (CA INDEX NAME)

● Br⁻

RN 753025-71-7 CAPLUS CN Sulfonium, [4-(methylthio)phenyl]diphenyl-, bromide (1:1) (CA INDEX NAME)

• Br

RN 753025-73-9 CAPLUS CN Sulfonium, (4-chlorophenyl)diphenyl-, bromide (1:1) (CA INDEX NAME)

● Br

RN 753025-75-1 CAPLUS
CN Sulfonium, diphenyl[4-(trifluoromethyl)phenyl]-, bromide (1:1) (CA INDEX NAME)

• Br

RN 753025-77-3 CAPLUS CN Sulfonium, bis(4-methylphenyl)phenyl-, bromide (1:1) (CA INDEX NAME)

• Br

RN 753025-78-4 CAPLUS
CN Sulfonium, bis(4-methoxyphenyl)phenyl-, bromide (1:1) (CA INDEX NAME)

● Br-

RN 753025-80-8 CAPLUS

CN Sulfonium, bis[4-(1,1-dimethylethyl)phenyl]phenyl-, bromide (1:1) (CA INDEX NAME)

Br⁻

RN 753025-81-9 CAPLUS

CN Sulfonium, bis(4-chlorophenyl)phenyl-, bromide (1:1) (CA INDEX NAME)

• Br-

RN 850345-82-3 CAPLUS

CN Sulfonium, [4-(1,1-dimethylethoxy)phenyl]diphenyl-, bromide (1:1) (CA INDEX NAME)

● Br⁻

RN 850345-83-4 CAPLUS

CN Sulfonium, 1-naphthalenyldiphenyl-, bromide (1:1) (CA INDEX NAME)

• Br-

RN 850345-84-5 CAPLUS

CN Sulfonium, phenylbis[4-(trifluoromethyl)phenyl]-, bromide (1:1) (CA INDEX NAME)

● Br⁻

IT 258872-06-9P 347841-66-1P 753025-64-8P

RL: CAT (Catalyst use); IMF (Industrial manufacture); RCT (Reactant); PREP (Preparation); RACT (Reactant or reagent); USES (Uses)

(process for producing triarylsulfonium salt for resist acid generator

and cationic polymerization catalysts)

RN 258872-06-9 CAPLUS

CN Sulfonium, [4-(1,1-dimethylethyl)phenyl]diphenyl-, bromide (1:1) (CA INDEX NAME)

Br-

RN 347841-66-1 CAPLUS

CN Sulfonium, (3-methylphenyl)diphenyl-, bromide (1:1) (CA INDEX NAME)

● Br⁻

RN 753025-64-8 CAPLUS

CN Sulfonium, (4-methoxyphenyl)diphenyl-, bromide (1:1) (CA INDEX NAME)

Br⁻

REFERENCE COUNT:

1 THERE ARE 1 CITED REFERENCES AVAILABLE FOR THIS RECORD. ALL CITATIONS AVAILABLE IN THE RE FORMAT

ANSWER 3 OF 18 CAPLUS COPYRIGHT 2008 ACS on STN

ACCESSION NUMBER:

2004:573030 CAPLUS

DOCUMENT NUMBER:

141:243157

TITLE:

Facile method for the preparation of triarylsulfonium

bromides using grignard reagents and

chlorotrimethylsilane as an activator

AUTHOR(S):

Imazeki, Shigeaki; Sumino, Motoshige; Fukasawa,

Kazuhito; Ishihara, Masami; Akiyama, Takahiko

07/06/200806/07/2008 Page 14

CORPORATE SOURCE: Chemical Products Research Laboratories, Wako Pure

Chemical Industries, Ltd., Kawagoe, 350-1101, Japan

SOURCE: Synthesis (2004), (10), 1648-1654

CODEN: SYNTBF; ISSN: 0039-7881

PUBLISHER: Georg Thieme Verlag

DOCUMENT TYPE: Journal LANGUAGE: English

OTHER SOURCE(S): CASREACT 141:243157

AB Triarylsulfonium bromides were synthesized by the reaction of diaryl sulfoxides with aryl Grignard reagents in the presence of TMSCI followed by treatment with HBr aqueous solution Trimethylsilyl chloride as activator is readily available and easier to handle than triethyloxonium tetrafluoroborate(1-) or trifluoromethanesulfonic acid trimethylsilyl ester. Triarylsulfonium bromides bearing three identical substituents on sulfur atom were synthesized by the treatment of di-Me sulfite or thionyl chloride with 5 equiv of Grignard reagent in the presence of TMSCI.

IT 3744-11-4P 54007-94-2P 469912-73-0P 469912-74-1P

RL: SPN (Synthetic preparation); PREP (Preparation) (preparation of triarylsulfonium bromides using Grignard reagents and di-Me sulfite or thionyl chloride as reactants and chlorotrimethylsilane as activator)

RN 3744-11-4 CAPLUS

CN Sulfonium, tris(4-methylphenyl)-, bromide (1:1) (CA INDEX NAME)

• Br-

RN 54007-94-2 CAPLUS

CN Sulfonium, tris(4-fluorophenyl)-, bromide (9CI) (CA INDEX NAME)

● Br-

RN 469912-73-0 CAPLUS
CN Sulfonium, tris[4-(1,1-dimethylethyl)phenyl]-, bromide (1:1) (CA INDEX NAME)

• Br-

RN 469912-74-1 CAPLUS CN Sulfonium, tris(4-methoxyphenyl)-, bromide (1:1) (CA INDEX NAME)

● Br-

IT 3353-89-7P, Triphenylsulfonium bromide 4189-82-6P 258872-06-9P 347841-66-1P 475598-78-8P

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10/576,299 07/06/2008
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● Br⁻

RN 4189-82-6 CAPLUS CN Sulfonium, (4-methylphenyl)diphenyl-, bromide (9CI) (CA INDEX NAME)

• Br

RN 258872-06-9 CAPLUS
CN Sulfonium, [4-(1,1-dimethylethyl)phenyl]diphenyl-, bromide (1:1) (CA INDEX NAME)

• Br-

RN 347841-66-1 CAPLUS

CN Sulfonium, (3-methylphenyl)diphenyl-, bromide (1:1) (CA INDEX NAME)

• Br -

RN 475598-78-8 CAPLUS
CN Sulfonium, (4-fluorophenyl)diphenyl-, bromide (1:1) (CA INDEX NAME)

● Br

RN 475598-82-4 CAPLUS
CN Sulfonium, bis(4-fluorophenyl)phenyl-, bromide (1:1) (CA INDEX NAME)

Br-

RN 753025-61-5 CAPLUS CN Sulfonium, (2-methylphenyl)diphenyl-, bromide (1:1) (CA INDEX NAME)

• Br

RN 753025-62-6 CAPLUS CN Sulfonium, (4-cyclohexylphenyl)diphenyl-, bromide (1:1) (CA INDEX NAME)

• Br

RN 753025-64-8 CAPLUS CN Sulfonium, (4-methoxyphenyl)diphenyl-, bromide (1:1) (CA INDEX NAME)

• Br-

RN 753025-66-0 CAPLUS
CN Sulfonium, (3-methoxyphenyl)diphenyl-, bromide (1:1) (CA INDEX NAME)

● Br⁻

RN 753025-68-2 CAPLUS CN Sulfonium, (4-butoxyphenyl)diphenyl-, bromide (1:1) (CA INDEX NAME)

Br⁻

RN 753025-70-6 CAPLUS
CN Sulfonium, (4-methoxy-3,5-dimethylphenyl)diphenyl-, bromide (1:1) (CA INDEX NAME)

• Br-

RN 753025-71-7 CAPLUS CN Sulfonium, [4-(methylthio)phenyl]diphenyl-, bromide (1:1) (CA INDEX NAME)

● Br

RN 753025-73-9 CAPLUS CN Sulfonium, (4-chlorophenyl)diphenyl-, bromide (1:1) (CA INDEX NAME)

● Br

RN 753025-75-1 CAPLUS
CN Sulfonium, diphenyl[4-(trifluoromethyl)phenyl]-, bromide (1:1) (CA INDEX NAME)

• Br

RN 753025-77-3 CAPLUS CN Sulfonium, bis(4-methylphenyl)phenyl-, bromide (1:1) (CA INDEX NAME)

● Br

RN 753025-78-4 CAPLUS
CN Sulfonium, bis(4-methoxyphenyl)phenyl-, bromide (1:1) (CA INDEX NAME)

• Br-

RN 753025-80-8 CAPLUS
CN Sulfonium, bis[4-(1,1-dimethylethyl)phenyl]phenyl-, bromide (1:1) (CA INDEX NAME)

● Br⁻

RN 753025-81-9 CAPLUS CN Sulfonium, bis(4-chlorophenyl)phenyl-, bromide (1:1) (CA INDEX NAME)

● Br-

RN 753025-82-0 CAPLUS

07/06/200806/07/2008 Page 22

CN Sulfonium, bis(4-hydroxyphenyl)phenyl-, bromide (1:1) (CA INDEX NAME)

● Br-

IT 3744-09-0P

RL: SPN (Synthetic preparation); PREP (Preparation) (preparation of triphenylsulfonium iodide using Grignard reagent and di-Ph sulfoxide as reactants and iodotrimethylsilane as activator)

RN 3744-09-0 CAPLUS.

CN Sulfonium, (4-methylphenyl)diphenyl-, iodide (9CI) (CA INDEX NAME)

• I-

REFERENCE COUNT: 23 THERE ARE 23 CITED REFERENCES AVAILABLE FOR THIS RECORD. ALL CITATIONS AVAILABLE IN THE RE FORMAT

ADDOORD. ALL CITATIONS AVAILABLE IN THE REPORTE

L5 ANSWER 4 OF 18 CAPLUS COPYRIGHT 2008 ACS on STN

ACCESSION NUMBER:

2004:565200 CAPLUS

DOCUMENT NUMBER:

141:123468

TITLE:

Preparation of fluoroarylsulfonium photoacid

generators for holographic recording media

INVENTOR(S):

Kolb, Eric S.; Cetin, Erdem A.; Hutchinson, Kirk D.;

Minns, Richard A.

PATENT ASSIGNEE(S):

Aprilis, Inc., USA PCT Int. Appl., 50 pp.

CODEN: PIXXD2

DOCUMENT TYPE:

Patent

LANGUAGE:

SOURCE:

English

FAMILY ACC. NUM. COUNT:

: 1

PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE		
WO 2004058699	A2	20040715	WO 2003-US41175	20031222		
WO 2004058699 W: AE, AG, AL	A3 , AM, AT	20040910 , AU, AZ, BA	, BB, BG, BR, BW, BY,	BZ, CA, CH,		

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CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, EG, ES, FI, GB, GD,
              GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP, KR, KZ, LC,
              LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NI, NO, NZ, OM, PG, PH, PL, PT, RO, RU, SC, SD, SE, SG, SK, SL, SY, TJ,
              TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, YU, ZA, ZM, ZW
          RW: BW, GH, GM, KE, LS, MW, MZ, SD, SL, SZ, TZ, UG, ZM, ZW, AM, AZ,
              BY, KG, KZ, MD, RU, TJ, TM, AT, BE, BG, CH, CY, CZ, DE, DK, EE,
              ES, FI, FR, GB, GR, HU, IE, IT, LU, MC, NL, PT, RO, SE, SI, SK,
              TR, BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG
                            A1
                                   20040722
                                               AU 2003-303482
                                                                         20031222
     AU 2003303482
     EP 1583740
                            A2
                                   20051012
                                                EP 2003-814368
                                                                         20031222
              AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC, PT,
              IE, SI, LT, LV, FI, RO, MK, CY, AL, TR, BG, CZ, EE, HU, SK
                                                US 2004-945151
     US 20050059543
                            A1
                                   20050317
                                                                         20040920
PRIORITY APPLN. INFO .:
                                                US 2002-436521P
                                                                         20021223
                                                                      P
                                                WO 2003-US41175
                                                                         20031222
OTHER SOURCE(S):
                           MARPAT 141:123468
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GI

AB The present invention discloses a new class of triarylsulfonium salt photoacid generators (PAGs) I (Arl = aryl substituted with 1 or more fluoroalkyl or F groups; Ar2-Ar7 = independently substituted or unsubstituted aryl), which are thermally stable and can be activated by long wavelength UV or visible light. The sulfonium PAGs of the present invention are addnl. soluble in monomers that can be polymerized by cationic polymerization chemical, and mixts. of said sulfonium PAGs and monomers can be stored for long periods of time without undergoing polymerization Furthermore, typical holog. recording media comprising one of these sulfonium PAGs, polymerizable monomer(s), a sensitizing dye, and a binder can be stored for long periods of time without exhibiting significant loss of recording sensitivity. Preferred sulfonium PAGs of the present invention are sulfonium PAGs substituted with one or more fluoro or fluoroalkyl groups.

Thus, treatment of di-Ph sulfoxide with trimethylsilyl trifluoromethanesulfonate, followed by a Grignard prepared from 3-bromobenzotrifluoride gave triarylsulfonium salt II after anion exchange with sodium tetrakis[3,5-bis(trifluoromethyl)phenyl]borate. Formulations containing II and related triarylsulfonium salts were tested for broadband and green sensitization by DSC. Polymerizable media containing the triarylsulfonium salts are also described, as are holog, recording media containing triarylsulfonium salts.

IT 153760-74-8 168153-17-1 723336-52-5 723336-53-6 723336-54-7 723336-56-9

723336-57-0 723336-59-2 723336-61-6

723336-62-7 723336-63-8

RL: CPS (Chemical process); DEV (Device component use); PEP (Physical, engineering or chemical process); PRP (Properties); PROC (Process); USES (Uses)

(preparation of fluoroarylsulfonium photoacid generators for holog. recording media)

RN 153760-74-8 CAPLUS

CN Sulfonium, triphenyl-, tetrakis(2,3,4,5,6-pentafluorophenyl)borate(1-) (1:1) (CA INDEX NAME)

CM 1

CRN 47855-94-7 CMF C24 B F20 CCI CCS

CM 2

CRN 18393-55-0 CMF C18 H15 S

```
RN 168153-17-1 CAPLUS
CN Sulfonium, triphenyl-, tetrakis[3,5-bis(trifluoromethyl)phenyl]borate(1-)
(9CI) (CA INDEX NAME)

CM 1

CRN 79230-20-9
CMF C32 H12 B F24
CCI CCS
```

CM 2

CRN 18393-55-0

CMF C18 H15 S

RN 723336-52-5 CAPLUS
CN Sulfonium, (4-methylphenyl)diphenyl-, tetrakis[3,5-bis(trifluoromethyl)phenyl]borate(1-) (9CI) (CA INDEX NAME)

CM 1

CRN 79230-20-9 CMF C32 H12 B F24 CCI CCS

CM 2

CRN 47045-31-8 CMF C19 H17 S

RN 723336-53-6 CAPLUS

Sulfonium, bis(4-methylphenyl)[3-(trifluoromethyl)phenyl]-, tetrakis[3,5-bis(trifluoromethyl)phenyl]borate(1-) (9CI) (CA INDEX NAME)

CM 1

CN

CRN 452068-63-2 CMF C21 H18 F3 S

CM 2

CRN 79230-20-9 CMF C32 H12 B F24 CCI CCS

RN 723336-54-7 CAPLUS

CN Sulfonium, bis(4-methylphenyl)[3-(trifluoromethyl)phenyl]-, tetrakis(pentafluorophenyl)borate(1-) (9CI) (CA INDEX NAME)

CM 1

CRN 452068-63-2 CMF C21 H18 F3 S

CM 2

CRN 47855-94-7 CMF C24 B F20

CCI CCS

RN 723336-56-9 CAPLUS

CN Sulfonium, (3-chlorophenyl)diphenyl-, tetrakis(pentafluorophenyl)borate(1) (9CI) (CA INDEX NAME)

CM 1

CRN 723336-55-8 CMF C18 H14 C1 S

CM 2

CRN 47855-94-7 CMF C24 B F20 CCI CCS

RN 723336-57-0 CAPLUS

CN Sulfonium, (3-chlorophenyl)diphenyl-, tetrakis[3,5-bis(trifluoromethyl)phenyl]borate(1-) (9CI) (CA INDEX NAME)

CM 1

CRN 723336-55-8 CMF C18 H14 C1 S

CM 2

CRN 79230-20-9 CMF C32 H12 B F24

cci ccs

723336-59-2 CAPLUS

CN Sulfonium, [3,5-bis(trifluoromethyl)phenyl]bis(4-methylphenyl)-, tetrakis(pentafluorophenyl)borate(1-) (9CI) (CA INDEX NAME)

CM 1

RN

CRN 723336-58-1 CMF C22 H17 F6 S

CM 2

CRN 47855-94-7 CMF C24 B, F20

CCI CCS

RN 723336-61-6 CAPLUS

CN Sulfonium, [3,5-bis(trifluoromethyl)phenyl]diphenyl-, tetrakis[3,5-bis(trifluoromethyl)phenyl]borate(1-) (9CI) (CA INDEX NAME)

CM 1

CRN 723336-60-5 CMF C20 H13 F6 S

CM 2

CRN 79230-20-9 CMF C32 H12 B F24

CCI CCS

RN 723336-62-7 CAPLUS

CN Sulfonium, [3,5-bis(trifluoromethyl)phenyl]diphenyl-, tetrakis(pentafluorophenyl)borate(1-) (9CI) (CA INDEX NAME)

CM 1

CRN 723336-60-5 CMF C20 H13 F6 S

CM 2

CRN 47855-94-7 CMF C24 B F20 CCI CCS

RN 723336-63-8 CAPLUS

CN Sulfonium, [3,5-bis(trifluoromethyl)phenyl]bis(4-methylphenyl)-, tetrakis[3,5-bis(trifluoromethyl)phenyl]borate(1-) (9CI) (CA INDEX NAME)

CM . 1

CRN 723336-58-1 CMF C22 H17 F6 S

CM 2

CRN 79230-20-9 CMF C32 H12 B F24

CCI CCS

IT 723336-50-3P 723336-51-4P

RL: CPS (Chemical process); DEV (Device component use); PEP (Physical, engineering or chemical process); PRP (Properties); SPN (Synthetic preparation); PREP (Preparation); PROC (Process); USES (Uses)

(preparation of fluoroarylsulfonium photoacid generators for holog. recording media)

RN 723336-50-3 CAPLUS

CN Sulfonium, diphenyl[3-(trifluoromethyl)phenyl]-, tetrakis(pentafluorophenyl)borate(1-) (9CI) (CA INDEX NAME)

CM 1

CRN 723336-48-9 CMF C19 H14 F3 S

CM 2

CRN 47855-94-7 CMF C24 B F20 CCI CCS

RN 723336-51-4 CAPLUS

CN Sulfonium, diphenyl[3-(trifluoromethyl)phenyl]-, tetrakis[3,5-bis(trifluoromethyl)phenyl]borate(1-) (9CI) (CA INDEX NAME)

CM 1

CRN 723336-48-9 CMF C19 H14 F3 S

CM 2

CRN 79230-20-9 CMF C32 H12 B F24 CCI CCS

$$\begin{array}{c|c}
F_3C & CF_3 \\
CF_3 & CF_3 \\
C & B & CF_3
\end{array}$$

$$CF_3 & CF_3$$

$$CF_3 & CF_3$$

$$CF_3 & CF_3$$

$$CF_3 & CF_3$$

IT 723336-49-0P

RL: RCT (Reactant); SPN (Synthetic preparation); PREP (Preparation); RACT (Reactant or reagent)

(preparation of fluoroarylsulfonium photoacid generators for holog.

recording media)

RN 723336-49-0 CAPLUS

CN Sulfonium, diphenyl[3-(trifluoromethyl)phenyl]-, 1,1,1-trifluoromethanesulfonate (1:1) (CA INDEX NAME)

CM 1

CRN 723336-48-9 CMF C19 H14 F3 S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

L5 ANSWER 5 OF 18 CAPLUS COPYRIGHT 2008 ACS on STN

ACCESSION NUMBER: 2002:888702 CAPLUS

DOCUMENT NUMBER: 137:392177

TITLE: Fluorinated triphenylsulfonium salts for acid

generators for resists or cationic photopolymn.

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10/576,299 07/06/2008
                          initiators
                          Ishihara, Masami; Sumino, Motoshige; Fukasawa,
INVENTOR(S):
                          Kazuhito; Maesawa, Tsuneaki; Imazeki, Shigeaki;
                          Sakuma, Yumi
                          Wako Pure Chemical Industries, Ltd., Japan
PATENT ASSIGNEE(S):
SOURCE:
                          PCT Int. Appl., 78 pp.
                          CODEN: PIXXD2
                          Patent
DOCUMENT TYPE:
                          Japanese
LANGUAGE:
FAMILY ACC. NUM. COUNT:
PATENT INFORMATION:
     PATENT NO.
                          KIND
                                  DATE
                                              APPLICATION NO.
                                                                       DATE
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     ______
                          ____
                                  _____
                                              WO 2002-JP4456
     WO 2002092559
                           A1
                                  20021121
                                                                       20020508
         W: AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BY, BZ, CA, CH, CN,
             CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, ES, FI, GB, GD, GE, GH,
             GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP, KR, KZ, LC, LK, LR,
             LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NO, NZ, OM, PH,
             PL, PT, RO, RU, SD, SE, SG, SI, SK, SL, TJ, TM, TN, TR, TT, TZ,
             UA, UG, US, UZ, VN, YU, ZA, ZM, ZW
         RW: GH, GM, KE, LS, MW, MZ, SD, SL, SZ, TZ, UG, ZM, ZW, AT, BE, CH, CY, DE, DK, ES, FI, FR, GB, GR, IE, IT, LU, MC, NL, PT, SE, TR, BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG
                                              AU 2002-309033 .
     AU 2002309033
                                  20021125
                           A1
                                                                       20020508
PRIORITY APPLN. INFO.:
                                                                    A 20010511
                                               JP 2001-141048
                                               JP 2001-141049
                                                                    A 20010511
                                              WO 2002-JP4456
                                                                    W
                                                                       20020508
OTHER SOURCE(S):
                          MARPAT 137:392177
     The title compds. have structures R1R22S+A1 and R33S+A2, where R1 is a
     monofluorophenyl optionally containing a substituent other than F, R2 is
     independently Ph optionally containing a substituent other than F, A1 is an
     anion resulting from a sulfonic or carboxylic acid having a F atom, R3 is
     independently fluorinated Ph optionally containing a substituent other than F,
     and A2 is an anion resulting from a sulfonic acid. Thus,
     4-fluorophenyldiphenylsulfonium nonafluorobutanesulfonate was prepared and
     mixed in a resist composition containing tert-Bu
acrylate-p-hydroxystyrene-styrene
     copolymer.
IT
     330812-90-3P 330812-91-4P 475598-74-4P
     475598-75-5P 475598-76-6P 475598-77-7P
     475598-80-2P 475598-81-3P 475598-83-5P
     475598-84-6P
     RL: CAT (Catalyst use); IMF (Industrial manufacture); PREP (Preparation);
     USES (Uses)
        (fluorinated triphenylsulfonium salts for acid generators for resists
        and cationic photopolymn. initiators)
RN
     330812-90-3 CAPLUS
CN
     Sulfonium, bis(4-fluorophenyl)phenyl-, 1,1,1-trifluoromethanesulfonate
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CRN 37181-39-8 CMF C F3 O3 S

(CA INDEX NAME)

CM . 2

CRN 29248-00-8 CMF C18 H13 F2 S

RN 330812-91-4 CAPLUS

CN Sulfonium, bis(4-fluorophenyl)phenyl-, 4-methylbenzenesulfonate (1:1) (CA INDEX NAME)

CM 1

CRN 29248-00-8 CMF C18 H13 F2 S

CM 2

CRN 16722-51-3 CMF C7 H7 O3 S

RN 475598-74-4 CAPLUS

CN Sulfonium, (4-fluorophenyl)diphenyl-, 1,1,2,2,3,3,4,4,4-nonafluoro-1-butanesulfonate (1:1) (CA INDEX NAME)

CM 1

CRN 70084-25-2 CMF C18 H14 F S

CM 2

CRN 45187-15-3 CMF C4 F9 O3 S

$$-03s-(CF_2)_3-CF_3$$

RN 475598-75-5 CAPLUS

CN Sulfonium, (4-fluorophenyl)diphenyl-, 1,1,2,2,3,3,4,4,5,5,6,6,7,7,8,8,8-heptadecafluoro-1-octanesulfonate (1:1) (CA INDEX NAME)

CM 1

CRN 70084-25-2 CMF C18 H14 F S

CM 2

CRN 45298-90-6 CMF C8 F17 O3 S

RN 475598-76-6 CAPLUS

CN Sulfonium, (4-fluorophenyl)diphenyl-, 2,3,4,5,6pentafluorobenzenesulfonate (1:1) (CA INDEX NAME)

CM 1

CRN 70084-25-2

CMF C18 H14 F S

CM 2

CRN 46377-88-2 CMF C6 F5 O3 S

RN 475598-77-7 CAPLUS

CN Sulfonium, (4-fluorophenyl)diphenyl-, 2,2,3,3,4,4,5,5,6,6,7,7,8,8,8-pentadecafluorooctanoate (1:1) (CA INDEX NAME)

CM 1

CRN 70084-25-2 CMF C18 H14 F S

CM 2

CRN 45285-51-6 CMF C8 F15 O2

F3C- (CF2)6-CO2-

RN 475598-80-2 CAPLUS

CN Sulfonium, (2,4-difluorophenyl)diphenyl-, 1,1,1-trifluoromethanesulfonate

07/06/200806/07/2008 Page 41

(1:1) (CA INDEX NAME)

CM 1

CRN 475598-79-9 CMF C18 H13 F2 S

CM 2

CRN· ·37181-39-8 CMF C F3 O3 S

RN 475598-81-3 CAPLUS

CN Sulfonium, bis(4-fluorophenyl)phenyl-, 1,1,2,2,3,3,4,4,4-nonafluoro-1-butanesulfonate (1:1) (CA INDEX NAME)

CM 1

CRN 45187-15-3 CMF C4 F9 O3 S

 $-03S-(CF_2)_3-CF_3$

CM 2

CRN 29248-00-8 CMF C18 H13 F2 S

RN 475598-83-5 CAPLUS

Page 42

CN Sulfonium, tris(4-fluorophenyl)-, 1,1,1-trifluoromethanesulfonate (1:1) (CA INDEX NAME)

CM 1

CRN 47197-44-4 CMF C18 H12 F3 S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 475598-84-6 CAPLUS

CN Sulfonium, tris(4-fluorophenyl)-, 1,1,2,2,3,3,4,4,4-nonafluoro-1-butanesulfonate (1:1) (CA INDEX NAME)

CM 1

CRN 47197-44-4 CMF C18 H12 F3 S

Page 43

CM 2

CRN 45187-15-3 CMF C4 F9 O3 S

 $-o_3s-(CF_2)_3-CF_3$

IT 54007-94-2P 475598-78-8P 475598-82-4P

RL: IMF (Industrial manufacture); RCT (Reactant); PREP (Preparation); RACT (Reactant or reagent)

(fluorinated triphenylsulfonium salts for acid generators for resists and cationic photopolymn. initiators)

RN 54007-94-2 CAPLUS

CN Sulfonium, tris(4-fluorophenyl)-, bromide (9CI) (CA INDEX NAME)

● Br-

RN 475598-78-8 CAPLUS

CN Sulfonium, (4-fluorophenyl)diphenyl-, bromide (1:1) (CA INDEX NAME)

• Br

RN 475598-82-4 CAPLUS

CN Sulfonium, bis(4-fluorophenyl)phenyl-, bromide (1:1) (CA INDEX NAME)

Br-

ANSWER 6 OF 18 CAPLUS COPYRIGHT 2008 ACS on STN

ACCESSION NUMBER:

2000:50072 CAPLUS

DOCUMENT NUMBER:

132:93801

TITLE:

Sulfonium salt and its manufacturing method

INVENTOR(S):

Park, Joo-Hyeon; Seo, Dong-Chul; Park, Sun-Ju; Kim,

APPITCATION NO

חמידע

Seong-Ju

PATENT ASSIGNEE(S):

Korea Kumho Petrochemical Co. Ltd., S. Korea

SOURCE:

Eur. Pat. Appl., 21 pp.

חמידים

CODEN: EPXXDW

DOCUMENT TYPE:

Patent

LANGUAGE:

English

KIND

FAMILY ACC. NUM. COUNT:

PATENT INFORMATION:

סמידאייי או

	PAI	ENT	NO.			KINI	,	DATE		AP	ΡЫΙ	CAT	ION	NO.			DATE	
	EP 972761 EP 972761				A1 B1	-	2000		-EP	19	999-	3055	52			19990		
		R:	AT,	•	CH,			ES,		GB, G	R,	IT,	LI,	LU,	NL,	SE	, MC,	PT,
	KR	2000	0088	11	•	A	•	2000	0215	KR	19	98-	2883	3			19980	716
	US	6111	143			Α		2000	0829	US	19	98-	1409	55			19980	827
	JР	2992	517			B2		1999	1220	JP	19	98-	2669	91			19980	921
	JP	2000	0342	74		Α		2000	0202									
	JP	2000	0445	35		Α		2000	0215	JP	19	99-	2340	35			19980	921
	TW	4827	54			В		2002	0411	TW	19	99-	8811	0428			19990	622
	AT	2106	41			${f T}$		2001	1215	AT	19	99-	3055	52			19990	713
	PT	9727	61			${f T}$		2002	0628	PT	19	99-	3055	52			19990	713
	ES	2169	938			Т3		2002	0716	ES	19	999-	3055	52			19990	713
	CN	1243	122		•	Α		2000	0202	CN	19	99-	1104	90			19990	716
PRIO	RİTY	APP	LN.	INFO	.:					KR	19	98-	2883	3		Α	19980	716
										EP	19	98-	3071	03		Α	19980	903
										JP	19	98-	2669	91		ΑЗ,	19980	921

MARPAT 132:93801 OTHER SOURCE(S):

This invention relates to a sulfonium salt, including its manufacturing method, which is effectively used as a photoacid initiator or radical photoinitiator during polymerization and a photoacid generator, leaving the protection groups of organic compds., especially as an useful photoacid generator

of the chemical amplified photoresist employed in semiconductor materials. Since the sulfonium salt of this invention, so prepared via one-step reaction between sulfoxide compound and aromatic compound in the presence of perfluoroalkanesulfonic anhydride, has the advantages in that by overcoming some shortcomings of the prior art to prepare the sulfonium salt via two steps using Grignard reagent, this invention may provide a novel sulfonium salt with higher yield which cannot be achieved

in the prior art and also to prepare even any conventional sulfonium salt having better yield. Ph sulfoxide dissolved in toluene was stirred at room temperature with a slow addition of triflic anhydride and further

stirred for 1 h. Then, the sulfonium salt contained in the reacting mixture was extracted with distilled water and further, toluene used as a solvent and reactant was removed. The sulfonium salt, so extracted with distilled water, was

 $% \left(1\right) =\left(1\right) +\left(

dichloromethane was removed under pressure. After the solvent was completely removed, an oil phase with larger viscosity was obtained. The oil phase, so formed, was completely dissolved in dichloromethane and with a slow addition of ether, a white precipitate was obtained. The white precipitate was

filtered and dried by vacuum oven to obtain the sulfonium salt in a white solid.

IT 66003-78-9P, Triphenylsulfonium triflate 81416-37-7P

111281-12-0P 116808-67-4P 116808-69-6P

145612-66-4P 154093-57-9P 180801-55-2P

240482-96-6P 255056-42-9P 255056-43-0P

255056-44-1P 255056-46-3P 255056-48-5P

255056-50-9P 255056-53-2P

RL: IMF (Industrial manufacture); PREP (Preparation) (sulfonium salt and its manufacturing method)

RN 66003-78-9 CAPLUS

CN Sulfonium, triphenyl-, 1,1,1-trifluoromethanesulfonate (1:1) (CA INDEX NAME)

CM 1

CRN 37181-39-8 CMF C F3 O3 S

CM 2

CRN 18393-55-0 CMF C18 H15 S

RN 81416-37-7 CAPLUS

CN Sulfonium, (4-methylphenýl)diphenyl-, 1,1,1-trifluoromethanesulfonate (1:1) (CA INDEX NAME)

CM 1

CRN 47045-31-8 CMF C19 H17 S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 111281-12-0 CAPLUS

CN Sulfonium, diphenyl[4-(phenylthio)phenyl]-, 1,1,1-trifluoromethanesulfonate (1:1) (CA INDEX NAME)

CM 1

CRN 47480-44-4 CMF C24 H19 S2

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 116808-67-4 CAPLUS

CN Sulfonium, (4-methoxyphenyl)diphenyl-, 1,1,1-trifluoromethanesulfonate (1:1) (CA INDEX NAME)

CM 1

CRN 70084-23-0 CMF C19 H17 O S

CM .2

CRN 37181-39-8 CMF C F3 O3 S

RN 116808-69-6 CAPLUS

CN Sulfonium, 1-naphthalenyldiphenyl-, salt with trifluoromethanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 116808-68-5 CMF C22 H17 S

CRN 37181-39-8 CMF C F3 O3 S

CN

RN 145612-66-4 CAPLUS

Sulfonium, [4-(1,1-dimethylethyl)phenyl]diphenyl-, 1,1,1-trifluoromethanesulfonate (1:1) (CA INDEX NAME)

CM 1

CRN 66482-54-0 CMF. C22 H23 S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 154093-57-9 CAPLUS

CN Sulfonium, (4-fluorophenyl)diphenyl-, salt with trifluoromethanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 70084-25-2 CMF C18 H14 F S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 180801-55-2 CAPLUS

CN Sulfonium, [4-[2-(1,1-dimethylethoxy)-2-oxoethoxy]phenyl]diphenyl-, 1,1,1-trifluoromethanesulfonate (1:1) (CA INDEX NAME)

CM 1

CRN 180801-54-1 CMF C24 H25 O3 S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 240482-96-6 CAPLUS

CN Sulfonium, (4-phenoxyphenyl)diphenyl-, 1,1,1-trifluoromethanesulfonate (1:1) (CA INDEX NAME)

CM 1

CRN 82617-07-0 CMF C24 H19 O S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 255056-42-9 CAPLUS
CN Sulfonium, [4-(2-methylpropyl)phenyl]diphenyl-, 1,1,1trifluoromethanesulfonate (1:1) (CA INDEX NAME)

CM 1

CRN 255056-41-8 CMF C22 H23 S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 255056-43-0 CAPLUS

CN Sulfonium, (4-chlorophenyl)diphenyl-, 1,1,1-trifluoromethanesulfonate (1:1) (CA INDEX NAME)

CM 1

CRN 47045-32-9 CMF C18 H14 C1 S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 255056-44-1 CAPLUS

CN Sulfonium, (4-bromophenyl)diphenyl-, 1,1,1-trifluoromethanesulfonate (1:1) (CA INDEX NAME)

CM 1

CRN 70244-60-9 CMF C18 H14 Br S

CRN 37181-39-8 CMF C F3 O3 S

RN 255056-46-3 CAPLUS

CN Sulfonium, (4-iodophenyl)diphenyl-, 1,1,1-trifluoromethanesulfonate (1:1) (CA INDEX NAME)

CM 1

CRN 255056-45-2 CMF C18 H14 I.S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 255056-48-5 · CAPLUS

CN Sulfonium, [4-[2-(1,1-dimethylethoxy)-2-oxoethoxy]-1-naphthalenyl]diphenyl-, 1,1,1-trifluoromethanesulfonate (1:1) (CA INDEX NAME)

CM 1

CRN 255056-47-4 CMF C28 H27 O3 S

CRN 37181-39-8 CMF C F3 O3 S

RN 255056-50-9 CAPLUS

CN Sulfonium, [4-[2-(1,1-dimethylethoxy)-2-oxoethoxy]-3-methylphenyl]diphenyl-, 1,1,1-trifluoromethanesulfonate (1:1) (CA INDEX NAME)

CM 1

CRN 255056-49-6 CMF C25 H27 O3 S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 255056-53-2 CAPLUS

CN Sulfonium, [4-[[2-(1,1-dimethylethoxy)-2-oxoethyl]thio]phenyl]diphenyl-, 1,1,1-trifluoromethanesulfonate (1:1) (CA INDEX NAME)

CM 1

CRN 255056-52-1 CMF C24 H25 O2 S2

$$S-CH_2-C-OBu-t$$
 $Ph \stackrel{+}{-} S$

CM 2

CRN 37181-39-8 CMF C F3 O3 S

REFERENCE COUNT: 12 THERE ARE 12 CITED REFERENCES AVAILABLE FOR THIS RECORD. ALL CITATIONS AVAILABLE IN THE RE FORMAT

L5 ANSWER 7 OF 18 CAPLUS COPYRIGHT 2008 ACS on STN

ACCESSION NUMBER: 1998:35993 CAPLUS

DOCUMENT NUMBER: 128:134385

ORIGINAL REFERENCE NO.:

REFERENCE NO.: 128:26277a,26280a

TITLE: Sulfonium salts and chemically-amplified

positive-working resists containing them

INVENTOR(S): Ozawa, Yoichi; Watanabe, Satoshi; Kukemura, Katsunari;

Nakura, Shigehiro; Tanaka, Hiroyoshi; Kawai, Yoshio

PATENT ASSIGNEE(S): Shin-Etsu Chemical Industry Co., Ltd., Japan; Nippon

Telegraph and Telephone Corp.

SOURCE: Jpn. Kokai Tokkyo Koho, 18 pp.

CODEN: JKXXAF

DOCUMENT TYPE: Patent

07/06/200806/07/2008 Page 55

LANGUAGE:

Japanese

FAMILY ACC. NUM. COUNT:

PATENT INFORMATION:

PATENT NO.	KIND	DATE	API	PLICATION NO.	DATE	
	-	- 				
JP 10007650	Α	19980113	JP	1996-307363		19961101
JP 3918881	B2	20070523				
TW 436663	В	20010528	TW	1996-85113247		19961030
US 5824824	Α	19981020	US	1996-742323		19961101
PRIORITY APPLN. INFO.:			JP	1995-309849	Α	19951102
OTHER SOURCE(S):	MARPAT	128:134385				
GI						

$$\begin{bmatrix} & & & & & & \\ & & & & \\ & & & & \\ & & & & \\ & & & & \\ & & & & \\ & & & & \\ & & & & \\ & & & & \\ & & \\ & & & \\ & & & \\ & & & \\ & & \\ & & & \\ & & & \\ & & \\ & & & \\ &$$

AB The sulfonium salts are represented by a Markush structure I (R1 = alkyl), alkoxy, alkylamino; OR2 = acid-instable group; Y = C2-20 linear or branched alkyl, cycloalkyl, arylsulfonate; if Y = alkyl, then ≥ 1 H bound to $non-\alpha-C$ is substituted with electron-withdrawing group such as F, NO2; if Y = arylsulfonate, then ≥ 1 H on the ring is substituted with electron-withdrawing group; n = 0-2; m = 1-3; q' = 1-5; p= 0-5; q = 0-4; q + q' = 1-5). The resists contain (A) an organic solvent, (B) an alkaline-soluble resin, (C) I, (D) a photoacid generator, and optionally (E) a dissoln. inhibitor containing acid-unstable group. Use of I prevents T-top formation in patterning even when time between exposure and post-exposure bake is long, and the resists are useful for microlithog.

199733-53-4P 199733-54-5P IT

RL: PNU (Preparation, unclassified); RCT (Reactant); PREP (Preparation); RACT (Reactant or reagent)

(preparation of sulfonium salts as photoacid generator for chemical-amplified

pos.-working resists)

RN199733-53-4 CAPLUS

Sulfonium, tris[4-(1,1-dimethylethoxy)phenyl]-, chloride (9CI) (CA INDEX CN NAME)

● cl-

• cl

```
157089-24-2P 157089-26-4P 160659-39-2P
    170632-61-8P 186769-06-2P 186889-18-9P
    186889-30-5P 202068-47-1P 202068-48-2P
    202068-49-3P 202068-50-6P 202068-51-7P
    202068-52-8P 202068-53-9P 202068-54-0P
    202068-55-1P 202068-57-3P 202068-58-4P
    RL: PNU (Preparation, unclassified); TEM (Technical or engineered material
    use); PREP (Preparation); USES (Uses)
        (preparation of sulfonium salts as photoacid generator for
chemical-amplified
       pos.-working resists)
RN
    157089-24-2 CAPLUS
CN
     Sulfonium, tris[4-(1,1-dimethylethoxy)phenyl]-, 1,1,1-
    trifluoromethanesulfonate (1:1) (CA INDEX NAME)
    CM
         1
    CRN
         137455-55-1
    CMF
         C30 H39 O3 S
```

CRN 37181-39-8 CMF C F3 O3 S

RN 157089-26-4 CAPLUS

CN Sulfonium, [4-(1,1-dimethylethoxy)phenyl]diphenyl-, salt with trifluoromethanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 157089-25-3 CMF C22 H23 O S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 160659-39-2 CAPLUS

CN Sulfonium, bis[4-(1,1-dimethylethoxy)phenyl]phenyl-, salt with trifluoromethanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 160659-38-1 CMF C26 H31 O2 S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 170632-61-8 CAPLUS

CN Sulfonium, bis[4-(dimethylamino)phenyl][4-(1,1-dimethylethoxy)phenyl]-, salt with trifluoromethanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 170632-60-7 CMF C26 H33 N2 O S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 186769-06-2 CAPLUS

Sulfonium, tris[4-(1,1-dimethylethoxy)phenyl]-, salt with pentafluorobenzenesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 137455-55-1 CMF C30 H39 O3 S

CM 2

CRN 46377-88-2 CMF C6 F5 O3 S

RN 186889-18-9 CAPLUS

CN Sulfonium, tris[3-(1,1-dimethylethoxy)phenyl]-, salt with trifluoromethanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186769-07-3 CMF C30 H39 O3 S

CRN 37181-39-8 CMF C F3 O3 S

RN 186889-30-5 CAPLUS

CN Sulfonium, [4-(dimethylamino)phenyl]bis[3-(1,1-dimethylethoxy)phenyl]-, salt with trifluoromethanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186889-29-2 CMF C28 H36 N O2 S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 202068-47-1 CAPLUS

CN Sulfonium, tris[4-(1,1-dimethylethoxy)phenyl]-, salt with 4-fluorobenzenesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 137455-55-1 CMF C30 H39 O3 S

CM 2

CRN 61657-38-3 CMF C6 H4 F O3 S

RN 202068-48-2 CAPLUS

CN Sulfonium, [4-(1,1-dimethylethoxy)phenyl]diphenyl-, salt with pentafluorobenzenesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 157089-25-3 CMF C22 H23 O S

CM 2

CRN 46377-88-2 CMF C6 F5 O3 S

RN 202068-49-3 CAPLUS

CN Sulfonium, [4-(dimethylamino)phenyl]bis[4-(1,1-dimethylethoxy)phenyl]-, salt with trifluoromethanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 197727-69-8 CMF C28 H36 N O2 S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 202068-50-6 CAPLUS

CN Sulfonium, bis[4-(1,1-dimethylethoxy)phenyl]phenyl-, salt with pentafluorobenzenesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 160659-38-1 CMF C26 H31 O2 S

CRN 46377-88-2 CMF C6 F5 O3 S

RN 202068-51-7 CAPLUS

CN Sulfonium, bis[4-(dimethylamino)phenyl][4-(1,1-dimethylethoxy)phenyl]-, salt with pentafluorobenzenesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 170632-60-7 . CMF C26 H33 N2 O S

CM 2

CRN 46377-88-2 CMF C6 F5 O3 S

RN 202068-52-8 CAPLUS

CN Sulfonium, [4-(dimethylamino)phenyl]bis[4-(1,1-dimethylethoxy)phenyl]-, salt with pentafluorobenzenesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 197727-69-8 CMF C28 H36 N O2 S

CM 2

CRN 46377-88-2 CMF C6 F5 O3 S

RN 202068-53-9 CAPLUS

CN Sulfonium, bis[3-(1,1-dimethylethoxy)phenyl]phenyl-, salt with 4-fluorobenzenesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186889-20-3 CMF C26 H31 O2 S

CM 2

CRN 61657-38-3 CMF C6 H4 F O3 S

RN 202068-54-0 CAPLUS

CN Sulfonium, bis[3-[2-(1,1-dimethylethoxy)-2-oxoethoxy]phenyl]phenyl-, salt with trifluoromethanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 201611-67-8 CMF C30 H35 O6 S

$$\begin{array}{c|c} O & Ph \\ \parallel \\ t\text{-BuO-C-CH}_2\text{-}O & S \\ \end{array} \\ \begin{array}{c|c} O & CH_2\text{-}C\text{-}OBu\text{-}t \\ \end{array}$$

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 202068-55-1 CAPLUS

CN Sulfonium, [4-[[(1,1-dimethylethoxy)carbonyl]oxy]phenyl]diphenyl-, salt with pentafluorobenzenesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 170632-68-5 CMF C23 H23 O3 S

CRN 46377-88-2 CMF C6 F5 O3 S

RN 202068-57-3 CAPLUS

CN Sulfonium, tris[4-[(tetrahydro-2-furanyl)oxy]phenyl]-, salt with pentafluorobenzenesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 202068-56-2 CMF C30 H33 O6 S

CM 2

CRN 46377-88-2 CMF C6 F5 O3 S

RN 202068-58-4 CAPLUS

CN Sulfonium, tris[3-[(tetrahydro-2H-pyran-2-yl)oxy]phenyl]-, salt with trifluoromethanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 195723-92-3 CMF C33 H39 O6 S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

L5 ANSWER 8 OF 18 CAPLUS COPYRIGHT 2008 ACS on STN

ACCESSION NUMBER:

1997:230496 CAPLUS

DOCUMENT NUMBER:

126:218586

ORIGINAL REFERENCE NO.:

126:42155a,42158a

TITLE:

Chemically-amplified positive-working resist

containing sulfonium photoacid generator

INVENTOR(S):

Oosawa, Yoichi; Takemura, Katsuya; Watanabe, Satoshi;

Ishihara, Toshinobu; Nagura, Shigehiro; Tanaka,

Haruyori; Kawai, Yoshio; Nakamura, Jiro

PATENT ASSIGNEE(S):

Shinetsu Chemical Industry Co., Ltd., Japan; Nippon

Telegraph & Telephone

SOURCE:

Jpn. Kokai Tokkyo Koho, 21 pp.

CODEN: JKXXAF

07/06/200806/07/2008 Page 68

DOCUMENT TYPE:

Patent

LANGUAGE:

Japanese

FAMILY ACC. NUM. COUNT:

1

PATENT INFORMATION:

PATENT NO.	KIND	DATE .	APPLICATION NO.	DATE
JP 09015848	A	19970117	JP 1995-186167	19950629
JP 3399166	B2	20030421		
PRIORITY APPLN. INFO.:			JP 1995-186167	19950629
OTHER SOURCE(S):	MARPAT	126:218586		

$$\begin{bmatrix} R^1 & Y^- & OR^2 \\ & & & \\ & & & \end{bmatrix}_n S^+ \begin{bmatrix} OR^2 & & \\ & & & \\ & & & \\ & & & \end{bmatrix}_m$$

AB The resist contains a sulfonium salt I [R1 = H, alkyl, alkoxy, dialkylamino; OR2 = acid-labile group; Y = (un)substituted alkyl- or arylsulfonate; n = 0-2, m = 1-3, m + n = 3]. The material provides high resolution patterns with good profile.

IT 170632-69-6 186889-52-1 188022-38-0

188022-42-6 188022-43-7

RL: CAT (Catalyst use); USES (Uses)

(chemical-amplified pos.-working resists containing sulfonium photoacid generators)

RN 170632-69-6 CAPLUS

CN Sulfonium, [4-[[(1,1-dimethylethoxy)carbonyl]oxy]phenyl]diphenyl-, salt with trifluoromethanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 170632-68-5 CMF C23 H23 O3 S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 186889-52-1 CAPLUS

CN Sulfonium, bis[3-[[(1,1-dimethylethoxy)carbonyl]oxy]phenyl]phenyl-, salt with 1,1,2,2,3,3,4,4,4-nonafluoro-1-butanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186889-51-0 CMF C28 H31 O6 S

$$\begin{array}{c|c} & & & & Ph & & & O \\ & & & & & & \\ t-BuO-C-O & & & & S & & \\ \end{array}$$

CM 2

CRN 45187-15-3 CMF C4 F9 O3 S

$$-03S-(CF_2)_3-CF_3$$

RN 188022-38-0 CAPLUS

CN Sulfonium, [3-[2-(1,1-dimethylethoxy)-2-oxoethoxy]phenyl]diphenyl-, salt with trifluoromethanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186889-53-2 CMF C24 H25 O3 S

CM 2

CRN 37181-39-8 CMF C.F3.O3 S

RN 188022-42-6 CAPLUS

CN Sulfonium, [3-[2-(1,1-dimethylethoxy)-2-oxoethoxy]phenyl]diphenyl-, salt with 4-methylbenzenesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186889-53-2 CMF C24 H25 O3 S

CM 2

CRN 16722-51-3 CMF C7 H7 O3 S

RN 188022-43-7 CAPLUS

CN Sulfonium, bis[3-[[(1,1-dimethylethoxy)carbonyl]oxy]phenyl]phenyl-, salt with 4-methylbenzenesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186889-51-0 CMF C28 H31 O6 S

CRN 16722-51-3 CMF C7 H7 O3 S

IT 186769-08-4P 186889-18-9P

RL: CAT (Catalyst use); PNU (Preparation, unclassified); PREP

(Preparation); USES (Uses)

(chemical-amplified pos.-working resists containing sulfonium photoacid generators)

RN 186769-08-4 CAPLUS

CN Sulfonium, tris[3-(1,1-dimethylethoxy)phenyl]-, salt with 4-methylbenzenesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186769-07-3 CMF C30 H39 O3 S

CM 2

CRN: 16722-51-3 CMF C7 H7 O3 S

RN 186889-18-9 CAPLUS

CN Sulfonium, tris[3-(1,1-dimethylethoxy)phenyl]-, salt with trifluoromethanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186769-07-3

CMF C30 H39 O3 S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

IT 186889-21-4P 186889-24-7P 186889-27-0P

186889-30-5P 186889-33-8P 186889-35-0P

186889-37-2P 186889-39-4P 186889-41-8P

186889-43-0P 186889-45-2P 186889-47-4P

186889-49-6P 186889-60-1P 188022-57-3P

RL: CAT (Catalyst use); PNU (Preparation, unclassified); PREP

(Preparation); USES (Uses)

(preparation of photoacid generator by Grignard reaction for photoresists)

RN 186889-21-4 CAPLUS

CN Sulfonium, bis[3-(1,1-dimethylethoxy)phenyl]phenyl-, salt with trifluoromethanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186889-20-3 CMF C26 H31 O2 S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 186889-24-7 CAPLUS

CN Sulfonium, [3-(1,1-dimethylethoxy)phenyl]diphenyl-, salt with trifluoromethanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186889-23-6 CMF C22 H23 O S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 186889-27-0 CAPLUS

CN Sulfonium, bis[4-(dimethylamino)phenyl][3-(1,1-dimethylethoxy)phenyl]-, salt with trifluoromethanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186889-26-9 CMF C26 H33 N2 O S

CRN 37181-39-8 CMF C F3 O3 S

CN

RN 186889-30-5 CAPLUS

Sulfonium, [4-(dimethylamino)phenyl]bis[3-(1,1-dimethylethoxy)phenyl]-, salt with trifluoromethanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186889-29-2 CMF C28 H36 N O2 S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 186889-33-8 CAPLUS

CN Sulfonium, bis[3-(1,1-dimethylethoxy)phenyl]phenyl-, salt with 4-methylbenzenesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186889-20-3 CMF C26 H31 O2 S

CM 2

CRN 16722-51-3 CMF C7 H7 O3 S

RN 186889-35-0 CAPLUS

CN Sulfonium, [3-(1,1-dimethylethoxy)phenyl]diphenyl-, salt with 4-methylbenzenesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186889-23-6 CMF C22 H23 O S

CM 2

CRN 16722-51-3 CMF C7 H7 O3 S

RN 186889-37-2 CAPLUS

CN Sulfonium, bis[4-(dimethylamino)phenyl][3-(1,1-dimethylethoxy)phenyl]-, salt with 4-methylbenzenesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186889-26-9 CMF C26 H33 N2 O S

CM 2

CRN 16722-51-3 CMF C7 H7 O3 S

RN 186889-39-4 CAPLUS

CN Sulfonium, [4-(dimethylamino)phenyl]bis[3-(1,1-dimethylethoxy)phenyl]-, salt with 4-methylbenzenesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186889-29-2 CMF C28 H36 N O2 S 10/576,299 07/06/2008

CM 2

CRN 16722-51-3 CMF C7 H7 O3 S

RN 186889-41-8 CAPLUS

CN Sulfonium, tris[3-(1,1-dimethylethoxy)phenyl]-, salt with 1,1,2,2,3,3,4,4,4-nonafluoro-1-butanesulfonic acid (1:1) (9CI) .(CA INDEX NAME)

CM 1

CRN 186769-07-3 CMF C30 H39 O3 S

CM 2

CRN 45187-15-3 CMF C4 F9 O3 S

 $-03S-(CF_2)_3-CF_3$

RN 186889-43-0 CAPLUS
CN Sulfonium, bis[3-(1,1-dimethylethoxy)phenyl]phenyl-, salt with
1,1,2,2,3,3,4,4,4-nonafluoro-1-butanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CRN 186889-20-3 CMF C26 H31 O2 S

CM 2

CRN 45187-15-3 CMF C4 F9 O3 S

 $-03S-(CF_2)_3-CF_3$

RN 186889-45-2 CAPLUS
CN Sulfonium, [3-(1,1-dimethylethoxy)phenyl]diphenyl-, salt with
1,1,2,2,3,3,4,4,4-nonafluoro-1-butanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186889-23-6 CMF C22 H23 O S

CM 2

CRN 45187-15-3 CMF C4 F9 O3 S

-03S- (CF2)3-CF3

RN 186889-47-4 CAPLUS
CN Sulfonium, bis[4-(dimethylamino)phenyl][3-(1,1-dimethylethoxy)phenyl]-, salt with 1,1,2,2,3,3,4,4,4-nonafluoro-1-butanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186889-26-9 CMF C26 H33 N2 O S

CM 2

CRN 45187-15-3 CMF C4 F9 O3 S

 $-03S-(CF_2)_3-CF_3$

RN 186889-49-6 CAPLUS
CN Sulfonium, [4-(dimethylamino)phenyl]bis[3-(1,1-dimethylethoxy)phenyl]-,
salt with 1,1,2,2,3,3,4,4,4-nonafluoro-1-butanesulfonic acid (1:1) (9CI)
(CA INDEX NAME)

CM 1

CRN 186889-29-2 CMF C28 H36 N O2 S

CM 2

CRN 45187-15-3 CMF C4 F9 O3 S

 $-03s-(CF_2)_3-CF_3$

10/576,299 07/06/2008

RN 186889-60-1 CAPLUS

CN Sulfonium, tris[3-[2-(1,1-dimethylethoxy)-2-oxoethoxy]phenyl]-, salt with 1,1,2,2,3,3,4,4,4-nonafluoro-1-butanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186889-59-8 CMF C36 H45 O9 S

CM 2

CRN 45187-15-3 CMF C4 F9 O3 S

-03S- (CF2)3-CF3

RN 188022-57-3 CAPLUS

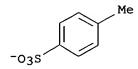
CN Sulfonium, [3-[[(1,1-dimethylethoxy)carbonyl]oxy]phenyl]diphenyl-, salt with 4-methylbenzenesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186889-56-5 CMF C23 H23 O3 S

CM 2

CRN 16722-51-3 CMF C7 H7 O3 S



L5 ANSWER 9 OF 18 CAPLUS COPYRIGHT 2008 ACS on STN

ACCESSION NUMBER: 1997:154980 CAPLUS

DOCUMENT NUMBER: 126:179054

ORIGINAL REFERENCE NO.: 126:34425a,34428a

TITLE: Preparation of triphenylsulfonium salts as acid

generating agents for chemically amplified positive

photoresists

INVENTOR(S): Oosawa, Yoichi; Takemura, Katsuya; Watanabe, Satoshi;

Ishihara, Toshinobu; Nagura, Shigehiro

PATENT ASSIGNEE(S): Shinetsu Chemical Industry Co., Ltd., Japan

SOURCE: Jpn. Kokai Tokkyo Koho, 17 pp.

CODEN: JKXXAF

DOCUMENT TYPE: Patent LANGUAGE: Japanese

FAMILY ACC. NUM. COUNT: 1

PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.		DATE
JP 09012537	Α	19970114	JP	1995-186168	19950629
JP 3606291	B2	20050105			
PRIORITY APPLN. INFO.:			JP	1995-186168	19950629
OTHER SOURCE(S):	MARPAT	126:179054			
CT					•

$$\begin{bmatrix} R^1 & Y^- & OR^2 \\ & & & \\ & & & \\ & & & \end{bmatrix}_m$$

AB Triphenylsulfonium salts [I; R1 = H, alkyl, alkoxy, dialkylamino; OR2. = acid-unstable group; Y = (un)substituted alkylsulfonate or arylsulfonate; n = 0-2; m = 1-3, n + m = 3] are prepared I are useful as components of chemical amplified pos. photoresists with high resolution and suitable for microlithog. of LSI. Thus, 28.6 g trimethylsilyl triflate was added dropwise to a solution of 17.8 g bis(3-tert-butoxyphenyl) sulfoxide and 5.3 g Et3N in DMF at <10° and stirred at 0-10° for 30 min, followed by adding dropwise a Grignard reagent prepared from 3-tert-butoxychlorobenzene and Mg in THF, and the resulting mixture was allowed to react at 0-10° for 30 min to give 29% tris(3-tert-butoxyphenyl)sulfonium triflate (II) of 99% purity. II showed mol. extinction coefficient of 12,200 at 248 nm (UV). A photoresist containing II,

poly(p-hydroxystyrene) tert-butoxycarbonate ester (alkali-soluble resin),

```
2,2'-bis(tert-butoxycarbonyloxyphenyl)propane (dissoln. inhibitor), and
     1-ethoxy-2-propanol was spin-coated at 0.8 μm thickness on a silicon
     wafer, baked at 100° for 120 s, exposed by an excimer laser
     stepper, baked st 90° for 60 s, and developed by 38% Me4NOH to give
     a pos. pattern with 5.0 Ml/cm2 sensitivity and 0.22 μM resolution
IT
     186769-08-4P, Tris(3-tert-butoxyphenyl)sulfonium
     4-toluenesulfonate 186889-18-9P, Tris(3-tert-
     butoxyphenyl)sulfonium trifluoromethanesulfonate 186889-21-4P,
     Bis(3-tert-butoxyphenyl)phenylsulfonium trifluoromethanesulfonate
     186889-24-7P, (3-tert-Butoxyphenyl)diphenylsulfonium
     trifluoromethanesulfonate 186889-27-0P, (3-tert-
     Butoxyphenyl)bis(4-dimethylaminophenyl)sulfonium trifluoromethanesulfonate
     186889-30-5P, Bis(3-tert-butoxyphenyl)(4-
     dimethylaminophenyl)sulfonium trifluoromethanesulfonate
     186889-33-8P, Bis(3-tert-butoxyphenyl)phenylsulfonium
     4-toluenesulfonate 186889-35-0P, (3-tert-
     Butoxyphenyl)diphenylsulfonium 4-toluenesulfonate 186889-37-2P,
     (3-tert-Butoxyphenyl)bis(4-dimethylaminophenyl)sulfonium
     4-toluenesulfonate 186889-39-4P, Bis(3-tert-butoxyphenyl)(4-
     dimethylaminophenyl)sulfonium 4-toluenesulfonate 186889-41-8P,
     Tris(3-tert-butoxyphenyl)sulfonium nonafluorobutanesulfonate
     186889-43-0P, Bis(3-tert-butoxyphenyl)phenylsulfonium
     nonafluorobutanesulfonate 186889-45-2P, (3-tert-
     Butoxyphenyl)diphenylsulfonium nonafluorobutanesulfonate
     186889-47-4P, (3-tert-Butoxyphenyl)bis(4-
     dimethylaminophenyl)sulfonium nonafluorobutanesulfonate
     186889-49-6P, Bis(3-tert-butoxyphenyl)(4-
     dimethylaminophenyl)sulfonium nonafluorobutanesulfonate
     186889-52-1P, Bis(3-tert-butoxycarbonyloxyphenyl)phenylsulfonium
     nonafluorobutanesulfonate 186889-54-3P, (3-tert-
     Butoxycarbonylmethyloxyphenyl)diphenylsulfonium nonafluorobutanesulfonate
     186889-57-6P, (3-tert-Butoxycarbonyloxyphenyl)diphenylsulfonium
     nonafluorobutanesulfonate 186889-60-1P, Tris(3-tert-
    \verb|butoxycarbony| lmethyloxyphenyl| \verb|sulfonium| nonafluorobutanesulfonate|
     RL: SPN (Synthetic preparation); TEM (Technical or engineered material
    use); PREP (Preparation); USES (Uses)
        (preparation of triphenylsulfonium salts as acid generating agents for
chemical
        amplified pos. photoresists)
RN
     186769-08-4 CAPLUS
     Sulfonium, tris[3-(1,1-dimethylethoxy)phenyl]-, salt with
CN
     4-methylbenzenesulfonic acid (1:1) (9CI) (CA INDEX NAME)
     CM
          1
         186769-07-3
     CRN
     CMF
        C30 H39 O3 S
```

CRN 16722-51-3 CMF C7 H7 O3 S

RN 186889-18-9 CAPLUS

CN Sulfonium, tris[3-(1,1-dimethylethoxy)phenyl]-, salt with trifluoromethanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186769-07-3 CMF C30 H39 O3 S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 186889-21-4 CAPLUS

CN Sulfonium, bis[3-(1,1-dimethylethoxy)phenyl]phenyl-, salt with trifluoromethanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186889-20-3 CMF C26 H31 O2 S

CRN 37181-39-8 CMF C F3 O3 S

RN 186889-24-7 CAPLUS

CN Sulfonium, [3-(1,1-dimethylethoxy)phenyl]diphenyl-, salt with trifluoromethanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186889-23-6 CMF C22 H23 O S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 186889-27-0 CAPLUS

CN Sulfonium, bis[4-(dimethylamino)phenyl][3-(1,1-dimethylethoxy)phenyl]-, salt with trifluoromethanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186889-26-9 CMF C26 H33 N2 O S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

CN

RN 186889-30-5 CAPLUS

Sulfonium, [4-(dimethylamino)phenyl]bis[3-(1,1-dimethylethoxy)phenyl]-, salt with trifluoromethanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186889-29-2 CMF C28 H36 N O2 S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 186889-33-8 CAPLUS

CN Sulfonium, bis[3-(1,1-dimethylethoxy)phenyl]phenyl-, salt with 4-methylbenzenesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186889-20-3 CMF C26 H31 O2 S

CM 2

CRN 16722-51-3 CMF C7 H7 O3 S

RN 186889-35-0 CAPLUS

CN Sulfonium, [3-(1,1-dimethylethoxy)phenyl]diphenyl-, salt with 4-methylbenzenesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186889-23-6 CMF C22 H23 O S

CM 2

10/576,299 07/06/2008

CRN 16722-51-3 CMF C7 H7 O3 S

RN 186889-37-2 CAPLUS

CN Sulfonium, bis[4-(dimethylamino)phenyl][3-(1,1-dimethylethoxy)phenyl]-, salt with 4-methylbenzenesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186889-26-9 CMF C26 H33 N2 O S

CM 2

CRN 16722-51-3 CMF C7 H7 O3 S

RN 186889-39-4 CAPLUS

CN Sulfonium, [4-(dimethylamino)phenyl]bis[3-(1,1-dimethylethoxy)phenyl]-, salt with 4-methylbenzenesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186889-29-2 CMF C28 H36 N O2 S

CRN 16722-51-3 CMF C7 H7 O3 S

RN 186889-41-8 CAPLUS

CN Sulfonium, tris[3-(1,1-dimethylethoxy)phenyl]-, salt with 1,1,2,2,3,3,4,4,4-nonafluoro-1-butanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186769-07-3 CMF C30 H39 O3 S

CM 2

CRN 45187-15-3 CMF C4 F9 O3 S

 $-03S-(CF_2)_3-CF_3$

RN 186889-43-0 CAPLUS
CN Sulfonium, bis[3-(1,1-dimethylethoxy)phenyl]phenyl-, salt with
1,1,2,2,3,3,4,4,4-nonafluoro-1-butanesulfonic acid (1:1) (9CI) (CA INDEX

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10/576,299 07/06/2008
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NAME)

CM 1

CRN 186889-20-3 CMF C26 H31 O2 S

CM 2

CRN 45187-15-3 CMF C4 F9 O3 S

 $-03S-(CF_2)_3-CF_3$

RN 186889-45-2 CAPLUS

CN Sulfonium, [3-(1,1-dimethylethoxy)phenyl]diphenyl-, salt with 1,1,2,2,3,3,4,4,4-nonafluoro-1-butanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186889-23-6 CMF C22 H23 O S

CM 2

CRN 45187-15-3 CMF C4 F9 O3 S

 $-03S-(CF_2)_3-CF_3$

RN 186889-47-4 CAPLUS
CN Sulfonium, bis[4-(dimethylamino)phenyl][3-(1,1-dimethylethoxy)phenyl]-,
salt with 1,1,2,2,3,3,4,4,4-nonafluoro-1-butanesulfonic acid (1:1) (9CI)
(CA INDEX NAME)

CRN 186889-26-9 CMF C26 H33 N2 O S

CM 2

CRN 45187-15-3 CMF C4 F9 O3 S

 $-03S-(CF_2)_3-CF_3$

RN 186889-49-6 CAPLUS

CN Sulfonium, [4-(dimethylamino)phenyl]bis[3-(1,1-dimethylethoxy)phenyl]-, salt with 1,1,2,2,3,3,4,4,4-nonafluoro-1-butanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186889-29-2 CMF C28 H36 N O2 S

CM 2

CRN 45187-15-3 CMF C4 F9 O3 S

 $-03S-(CF_2)_3-CF_3$

RN 186889-52-1 CAPLUS

CN Sulfonium, bis[3-[[(1,1-dimethylethoxy)carbonyl]oxy]phenyl]phenyl-, salt with 1,1,2,2,3,3,4,4,4-nonafluoro-1-butanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186889-51-0 CMF C28 H31 O6 S

CM 2

CRN 45187-15-3 CMF C4 F9 O3 S

-03S- (CF2)3-CF3

RN 186889-54-3 CAPLUS

CN Sulfonium, [3-[2-(1,1-dimethylethoxy)-2-oxoethoxy]phenyl]diphenyl-, salt with 1,1,2,2,3,3,4,4,4-nonafluoro-1-butanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186889-53-2 CMF C24 H25 O3 S

CM 2

CRN 45187-15-3 CMF C4 F9 O3 S

 $^{-}$ O3S $^{-}$ (CF2)3 $^{-}$ CF3

RN 186889-57-6 CAPLUS

07/06/200806/07/2008 Page 92

CN Sulfonium, [3-[[(1,1-dimethylethoxy)carbonyl]oxy]phenyl]diphenyl-, salt with 1,1,2,2,3,3,4,4,4-nonafluoro-1-butanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186889-56-5 CMF C23 H23 O3 S

CM 2

CRN 45187-15-3 CMF C4 F9 O3 S

 $-03S-(CF_2)_3-CF_3$

RN 186889-60-1 CAPLUS

CN Sulfonium, tris[3-[2-(1,1-dimethylethoxy)-2-oxoethoxy]phenyl]-, salt with 1,1,2,2,3,3,4,4,4-nonafluoro-1-butanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186889-59-8 CMF C36 H45 O9 S

CM 2

CRN 45187-15-3 CMF C4 F9 O3 S -03S- (CF2)3-CF3

L5 ANSWER 10 OF 18 CAPLUS COPYRIGHT 2008 ACS on STN

ACCESSION NUMBER:

1997:97151 CAPLUS

DOCUMENT NUMBER:

126:104070

ORIGINAL REFERENCE NO.:

126:20081a,20084a

TITLE:

Preparation of (3,4-methylenedioxy- or

3,4-isopropylidenedioxyphenyl)diphenylsulfonium salts

as acid-generating agents and chemical

amplification-type positive-working photoresist

material containing them

INVENTOR(S):

Oosawa, Yoichi; Watanabe, Satoshi; Shimada, Junji; Takemura, Katsuya; Nagura, Shigehiro; Ishihara,

APPLICATION NO.

DATE

Toshinobu

PATENT ASSIGNEE(S):

Shinetsu Chemical Industry Co., Ltd., Japan

Jpn. Kokai Tokkyo Koho, 19 pp.

CODEN: JKXXAF

DATE

DOCUMENT TYPE:

Patent

KIND

LANGUAGE:

SOURCE:

Japanese

FAMILY ACC. NUM. COUNT:

PATENT INFORMATION:

PATENT NO.

		KIND	DATE	ATTHICATION NO.	DATE
	JP 08325259 JP 3601548	A B2	19961210 20041215	JP 1995-155141	19950530
PRIO	RITY APPLN. INFO.:			JP 1995-155141	19950530
		MARPAT	126:104070		1330000
AB	The title compds. (I : R1 =	H, alkvl, a	lkoxy, dialkylamino; R2	R3 = H.
				r to form a ring; Y =	,
				n = 0-2; m = 1-3 and 1	n + m = 3)
	are prepared A cher	nical a	mplification	-type posworking phot	oresist material
	containing I is claim	imed.	I can increa	se dissoln. contrast be	tween exposed and
	unexposed part and s	shifts	the maximum	absorption wavelength to	o a longer
				near 250 nm owing to the	
	electro-donating eff	fect of	the substit	uents, and are suitable	as
	components for chemi	ical am	plification-	type posworking photo	resist material
	with high resolution	n in mi	crolithog.	This photoresist posses	s high
	sensitivity for high	n energ	y rays such	as far-UV, electron bear	m, and
				resolution, plasma etch	
				tern, and may be used for	or far-UV
				ufacturing LSI. Thus,	
				ulfoxide was dissolved	
	THF and ice-cooled,	follow	ed by adding	Et3N and adding dropwi	se
	trimethylsilyl trif	late, a	nd to the re	sulting solution was add	ded dropwise a
	Grignard reagent pre	epared	from 1,2-(is	opropylidenedioxy)-4-	
	bromobenzene and mg	metal	at <10 $^\circ$ to g	ive, after aging the re-	action
	mixture at 0-10° for				
	(isopropylidenedioxy	y) pheny	l]sulfonium	triflate (II). A photo	resist containing
	II 5, $2,2-bis[4-(ter)]$	rt-buto:	xycarbonylox	y)phenyl]propane (disso	ln.
	inhibitor) 20, and t	tert-bu	toxycarbonyl	ated poly(4-hydroxystyr	ene) 70, and
	1-ethoxy-2-propanol	450 pa.	rt was spin-	coated to 0.8 µm thickn	ess on a
•	silicon water, baked	d for 1	20 s on a ho	t plate, exposed by an	excimer laser
	stepper, baked at 90	tor	60 s, and de	veloped by 2.38% aqueou	s
	tetramethylammonlum	nyarox	ide solution	to give a pos. pattern	with 6.5 mJ/cm2

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sensitivity and 0.24 \mu m resolution
IT
     66003-78-9P, Triphenylsulfonium triflate 138888-95-6P
     186001-64-9P 186001-66-1P 186001-68-3P
     186001-70-7P 186001-72-9P 186001-74-1P
     186001-76-3P 186001-77-4P 186001-78-5P
     186001-79-6P 186001-80-9P 186001-81-0P
     RL: SPN (Synthetic preparation); TEM (Technical or engineered material
     use); PREP (Preparation); USES (Uses)
        (preparation of (methylenedioxy- or isopropylidenedioxyphenyl)diphenylsulfon
        ium salts as acid-generating agents for chemical amplification-type
        pos.-working photoresists)
RN
     66003-78-9 CAPLUS
CN
     Sulfonium, triphenyl-, 1,1,1-trifluoromethanesulfonate (1:1) (CA INDEX
     NAME)
     CM
          1
     CRN
          37181-39-8
     CMF C F3 O3 S
    - so<sub>3</sub>-
          2
     CM
     CRN
          18393-55-0
     CMF
          C18 H15 S
   Ph
Ph = S + Ph
RN
     138888-95-6 CAPLUS
CN
     Sulfonium, tris[4-[[(1,1-dimethylethoxy)carbonyl]oxy]phenyl]-, salt with
     trifluoromethanesulfonic acid (1:1) (9CI) (CA INDEX NAME)
     CM
          1
     CRN
          120397-65-1
     CMF C33 H39 O9 S
```

CRN 37181-39-8 CMF C F3 O3 S

RN 186001-64-9 CAPLUS

CN Sulfonium, tris(2,2-dimethyl-1,3-benzodioxol-5-yl)-, salt with trifluoromethanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186001-63-8 CMF C27 H27 O6 S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 186001-66-1 CAPLUS

CN Sulfonium, 1,3-benzodioxol-5-ylbis[4-(1,1-dimethylethoxy)phenyl]-, salt with trifluoromethanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186001-65-0 CMF C27 H31 O4 S⁻

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 186001-68-3 CAPLUS

CN Sulfonium, (2,2-dimethyl-1,3-benzodioxol-5-yl)diphenyl-, salt with 1,1,2,2,3,3,4,4,4-nonafluoro-1-butanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186001-67-2 CMF C21 H19 O2 S

CRN 45187-15-3 CMF C4 F9 O3 S

 $-03S-(CF_2)_3-CF_3$

RN 186001-70-7 CAPLUS

CN Sulfonium, bis[4-(dimethylamino)phenyl](2,2-dimethyl-1,3-benzodioxol-5-yl)-, salt with trifluoromethanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186001-69-4 CMF C25 H29 N2 O2 S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 186001-72-9 CAPLUS

CN Sulfonium, bis (2,2-dimethyl-1,3-benzodioxol-5-yl) [4-(1,1-

dimethylethoxy)phenyl]-, salt with trifluoromethanesulfonic acid (1:1)
(9CI) (CA INDEX NAME)

CM 1

CRN 186001-71-8 CMF C28 H31 O5 S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

CM 1

CRN 186001-73-0 CMF C29 H35 O4 S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 186001-76-3 CAPLUS

CN Sulfonium, bis(2,2-dimethyl-1,3-benzodioxol-5-yl)phenyl-, salt with trifluoromethanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186001-75-2 CMF C24 H23 O4 S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 186001-77-4 CAPLUS

CN Sulfonium, tris(2,2-dimethyl-1,3-benzodioxol-5-yl)-, salt with 4-methylbenzenesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186001-63-8 CMF C27 H27 O6 S

CRN 16722-51-3 CMF C7 H7 O3 S

RN

186001-78-5 CAPLUS Sulfonium, 1,3-benzodioxol-5-ylbis[4-(1,1-dimethylethoxy)phenyl]-, salt with 4-methylbenzenesulfonic acid (1:1) (9CI) (CA INDEX NAME) CN

CM

CRN 186001-65-0 CMF C27 H31 O4 S

CM 2

CRN 16722-51-3 CMF C7 H7 O3 S

RN 186001-79-6 CAPLUS

CN Sulfonium, (2,2-dimethyl-1,3-benzodioxol-5-yl)diphenyl-, salt with 4-methylbenzenesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186001-67-2 CMF C21 H19 O2 S

CM 2

CRN 16722-51-3 CMF C7 H7 O3 S

RN 186001-80-9 CAPLUS

CN Sulfonium, bis[4-(dimethylamino)phenyl](2,2-dimethyl-1,3-benzodioxol-5-yl)-, salt with 4-methylbenzenesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186001-69-4 CMF C25 H29 N2 O2 S

$$\begin{array}{c} \text{Me}_2\text{N} \\ \text{S}^+ \\ \text{O} \\ \text{Me} \\ \text{NMe}_2 \\ \end{array}$$

CRN 16722-51-3 CMF C7 H7 O3 S

RN 186001-81-0 CAPLUS
CN Sulfonium, bis(2,2-dimethyl-1,3-benzodioxol-5-yl)[4-(1,1-dimethylethoxy)phenyl]-, salt with 4-methylbenzenesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 186001-71-8 CMF C28 H31 O5 S

CM 2

CRN 16722-51-3 CMF C7 H7 O3 S

L5 ANSWER 11 OF 18 CAPLUS COPYRIGHT 2008 ACS on STN

ACCESSION NUMBER:

1996:748363 CAPLUS

DOCUMENT NUMBER:

126:31153

ORIGINAL REFERENCE NO.:

126:6337a,6340a

TITLE:

Preparation of phenylsulsonium salts as acid generating agents for highly sensitive positive

photoresist materials

INVENTOR(S):

Oosawa, Yoichi; Watanabe, Satoshi; Shimada, Junji;

Takemura, Katsuya; Ishihara, Toshinobu

PATENT ASSIGNEE(S):

Shinetsu Chemical Industry Co., Ltd., Japan

SOURCE:

Jpn. Kokai Tokkyo Koho, 18 pp.

DOCUMENT TYPE:

CODEN: JKXXAF Patent

LANGUAGE:

Japanese

FAMILY ACC. NUM. COUNT:

PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
JP 08245566	Α	19960924	JP 1995-84424	19950307
PRIORITY APPLN. INFO.:			JP 1995-84424	19950307
OTHER SOURCE(S):	MARPAT	126:31153		
GI				

The title compds. (I; R1 = H, alkyl, alkoxy, dialkylamino; R2, R3 =Me3CO; Y = CF3SO3, p-TsO; n = 0-2; m = 1-3; n + m = 3) are prepared I are useful as components for chemical amplification-type photoresist materials in micro-process technic. Thus, bis(4-tert-butoxyphenyl) sulfoxide was reacted with CF3SO3SiMe3 in the presence of Et3N, and then reacted with 1,2-di-tert-butoxy-4-chlorobenzene and Mg to give 35% I (R1 = 4'-Me3CO, R2 = 3-Me3CO, R3 =4-Me3CO, Y = CF3SO3, n = 2, m = 1) (II). II showed sensitivity optimum exposure of 5.5 mJ/cm2.

IT 184291-51-8P 184291-53-0P 184291-55-2P 184291-57-4P 184291-59-6P 184291-61-0P

184291-63-2P 184291-66-5P

RL: SPN (Synthetic preparation); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses)

(preparation of phenylsulsonium salts as acid generating agents for highly sensitive pos. photoresist materials) $\,$

RN 184291-51-8 CAPLUS

CN Sulfonium, [3,4-bis(1,1-dimethylethoxy)phenyl]bis[4-(1,1-dimethylethoxy)phenyl]-, salt with trifluoromethanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 184291-50-7 CMF C34 H47 O4 S

CM 2

·CRN 37181-39-8 CMF C F3 O3 S

RN 184291-53-0 CAPLUS
CN Sulfonium, [2,4-bis(1,1-dimethylethoxy)phenyl]bis[4-(1,1-dimethylethoxy)phenyl]-, salt with trifluoromethanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 184291-52-9 CMF C34 H47 O4 S

CRN 37181-39-8 CMF C F3 O3 S

RN 184291-55-2 CAPLUS

CN Sulfonium, tris[3,4-bis(1,1-dimethylethoxy)phenyl]-, salt with trifluoromethanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 184291-54-1 CMF C42 H63 O6 S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 184291-57-4 CAPLUS

CN Sulfonium, [2,4-bis(1,1-dimethylethoxy)phenyl]diphenyl-, salt with

07/06/200806/07/2008 Page 106

trifluoromethanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 184291-56-3 CMF C26 H31 O2 S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 184291-59-6 CAPLUS

CN Sulfonium, [3,4-bis(1,1-dimethylethoxy)phenyl]diphenyl-, salt with trifluoromethanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 184291-58-5 CMF C26 H31 O2 S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

CM 1

CRN 184291-52-9 CMF C34 H47 O4 S

CM 2

CRN 16722-51-3 CMF C7 H7 O3 S

CM 1

CRN 184291-50-7 CMF C34 H47 O4 S

CRN 16722-51-3 CMF C7 H7 O3 S

RN 184291-66-5 CAPLUS

CN Sulfonium, tris[3,4-bis(1,1-dimethylethoxy)phenyl]-, salt with 4-methylbenzenesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 184291-54-1 CMF C42 H63 O6 S

CM 2

CRN 16722-51-3 CMF C7 H7 O3 S

L5 ANSWER 12 OF 18 CAPLUS COPYRIGHT 2008 ACS on STN

ACCESSION NUMBER:

. 1996:169329 CAPLUS

DOCUMENT NUMBER:

124:274529

ORIGINAL REFERENCE NO.:

124:50535a,50538a

TITLE:

Chemical amplification positive-working resist

materials

INVENTOR(S):

Watanabe, Satoshi; Oikawa, Katsuyuki; Ishihara,

Toshinobu; Tanaka, Haruyori; Matsuda, Korehito; Kawai,

Yoshio

PATENT ASSIGNEE(S):

Shinetsu Chemical Industry Co., Ltd., Japan; Nippon

Telegraph & Telephone

SOURCE:

Jpn. Kokai Tokkyo Koho, 14 pp.

CODEN: JKXXAF

DOCUMENT TYPE:

Patent

LANGUAGE:

Japanese

FAMILY ACC. NUM. COUNT:

PATENT INFORMATION:

PATENT NO.	KIND	DATE	AP	PLICATION NO.		DATE
JP 07333834	 А	19951222	JP	 1994-152655		19940610
JP 2964874	B2	19991018	-	1001 1000		13340010
US 5624787	Α	19970429	US	1995-466690		19950606
TW 390973	В	20000521	TW	1995-84105763		19950607
KR 212928	B1	19990802	KR	1995-15295		19950610
PRIORITY APPLN. INFO.:			JP	1994-152655	Α	19940610
OTHER SOURCE(S):	MARPAT	124:274529				
GT						

The title materials contain a sulfonium salt I (R1 = H, alkyl, alkoxy; Y- = CF3SO3-, p-MeC6H4SO3-) and a N-containing compound The materials show high sensitivity toward KrF excimer lasers and resistance to plasma etching and provide high-resolution patterns with good thermal resistance. Thus, a resist comprised I (R1 = H, Y- = CF3SO3-), N-methylpyrrolidone, an alkali-soluble resin, and a dissoln. inhibitor.

IT 157089-24-2P 160659-39-2P 161453-47-0P 170014-77-4P

RL: MOA (Modifier or additive use); PNU (Preparation, unclassified); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses) (acid generator; chemical amplification-type pos.-working photoresist containing sulfonium salt and nitrogen-containing compound)

RN 157089-24-2 CAPLUS

CN Sulfonium, tris[4-(1,1-dimethylethoxy)phenyl]-, 1,1,1-trifluoromethanesulfonate (1:1) (CA INDEX NAME)

CM 1

CRN 137455-55-1 CMF C30 H39 O3 S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 160659-39-2 CAPLUS

CN Sulfonium, bis[4-(1,1-dimethylethoxy)phenyl]phenyl-, salt with trifluoromethanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 160659-38-1 CMF C26 H31 O2 S 10/576,299 07/06/2008

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 161453-47-0 CAPLUS

CN Sulfonium, bis[4-(1,1-dimethylethoxy)phenyl]phenyl-, 4-methylbenzenesulfonate (1:1) (CA INDEX NAME)

CM 1

CRN 160659-38-1 CMF C26 H31 O2 S

CM 2

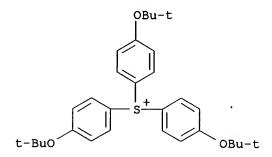
CRN 16722-51-3 CMF C7 H7 O3 S

RN 170014-77-4 CAPLUS

CN Sulfonium, tris[4-(1,1-dimethylethoxy)phenyl]-, 4-methylbenzenesulfonate (1:1) (CA INDEX NAME)

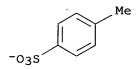
CM 1

CRN 137455-55-1 CMF C30 H39 O3 S



CM 2

CRN 16722-51-3 CMF C7 H7 O3 S



L5 ANSWER 13 OF 18 CAPLUS COPYRIGHT 2008 ACS on STN

ACCESSION NUMBER: 1990:458341 CAPLUS

DOCUMENT NUMBER: 113:58341

ORIGINAL REFERENCE NO.: 113:9859a,9862a

TITLE: Photochemistry of triarylsulfonium salts

AUTHOR(S): Dektar, John L.; Hacker, Nigel P.

CORPORATE SOURCE: Almaden Res. Cent., IBM Res. Div., San Jose, CA,

95120-6099, USA

SOURCE: Journal of the American Chemical Society (1990),

112(16), 6004-15

CODEN: JACSAT; ISSN: 0002-7863

DOCUMENT TYPE: Journal LANGUAGE: English

OTHER SOURCE(S): CASREACT 113:58341

The photolysis of triphenylsulfonium, tris(4-methylphenyl)sulfonium, tris(4-chlorophenyl)sulfonium, several monosubstituted (4-F, 4-Cl, 4-Me, 4-MeO, 4-PhS, and 4-PhCO), and disubstituted [4,4'-Me2 and 4,4'-(MeO)2] triphenylsulfonium salts was examined in solution Direct irradiation of triphenylsulfonium salts produced new rearrangement products, phenylthiobiphenyls, along with di-Ph sulfide, which had been previously reported. Similarly, the triarylsulfonium salts, with the exception of the [4-(phenylthio)phenyl]diphenylsulfonium salts, gave the new rearrangement products. The mechanism for direct photolysis is proposed to occur from the singlet excited state to give a predominant heterolytic cleavage along with some homolytic cleavage. The heterolytic cleavage gives Ph cation and di-Ph sulfide, whereas homolytic cleavage gives the singlet Ph radical and diphenylsulfinyl radical cation pair. These pairs

of intermediates then produce the observed photoproducts by an in-cage recombination mechanism and also by reactions with the solvent. The effect of solvent viscosity, solvent polarity, anion, and aryl substituent was examined The triplet sensitization of the sulfonium salts was also investigated. In contrast to previous reports, the triplet state of the sulfonium salt is labile, leading to a triplet geminate radical pair of Ph radical and diphenylsulfinyl radical cation. These species ultimately form benzene and di-Ph sulfide as products. Direct photolysis of the [4-(phenylthio)phenyl]diphenylsulfonium salt gave exclusively di-Ph sulfide, benzene, and acid and decomps. via the triplet excited state. ΙT 3353-89-7P, Triphenylsulfonium bromide 57840-38-7P 62770-64-3P 66003-78-9P, Triphenylsulfonium triflate 71449-78-0P 77785-82-1P 125853-08-9P 127279-74-7P 127820-38-6P 127820-39-7P 127855-15-6P 127855-16-7P 127855-18-9P 127855-20-3P 127855-21-4P 127855-22-5P 127855-24-7P RL: RCT (Reactant); SPN (Synthetic preparation); PREP (Preparation); RACT (Reactant or reagent) (preparation and photolysis of, mechanism of) RN 3353-89-7 CAPLUS Sulfonium, triphenyl-, bromide (1:1) (CA INDEX NAME) CN Ph Ph - S + Ph● Br⁻ RN 57840-38-7 CAPLUS CN Sulfonium, triphenyl-, (OC-6-11)-hexafluoroantimonate(1-) (1:1) (CA INDEX NAME) CM 1 CRN . 18393-55-0 CMF C18 H15 S ₽h CM

17111-95-4

F6 Sb

CCS

CRN

CMF

CCI

RN 62770-64-3 CAPLUS
CN Sulfonium, tris(4-methylphenyl)-, (OC-6-11)-hexafluoroantimonate(1-) (9CI)
(CA INDEX NAME)

CM 1

CRN 47197-43-3 CMF C21 H21 S

CM 2

CRN 17111-95-4 CMF F6 Sb CCI CCS

RN 66003-78-9 CAPLUS

CN Sulfonium, triphenyl-, 1,1,1-trifluoromethanesulfonate (1:1) (CA INDEX NAME)

CM 1

CRN 37181-39-8 CMF C F3 O3 S

CM 2

CRN 18393-55-0 CMF C18 H15 S

RN 71449-78-0 CAPLUS

CN Sulfonium, diphenyl[4-(phenylthio)phenyl]-, (OC-6-11)-hexafluoroantimonate(1-) (1:1) (CA INDEX NAME)

CM 1

CRN 47480-44-4 CMF C24 H19 S2

CM 2

CRN 17111-95-4 CMF F6 Sb . CCI CCS

RN 77785-82-1 CAPLUS
CN Sulfonium, (4-chlorophenyl)diphenyl-, (OC-6-11)-hexafluoroantimonate(1-) (9CI) (CA INDEX NAME)

CM 1

CRN 47045-32-9 CMF C18 H14 C1 S

CM 2

CRN 17111-95-4 CMF F6 Sb CCI CCS

RN 125853-08-9 CAPLUS
CN Sulfonium, tris(4-chlorophenyl)-, (OC-6-11)-hexafluoroantimonate(1-) (9CI)
(CA INDEX NAME)

CM 1

CRN 125853-07-8 CMF C18 H12 C13 S

CRN 17111-95-4 CMF F6 Sb CCI CCS

RN 127279-74-7 CAPLUS

CN Sulfonium, (4-methoxyphenyl)diphenyl-, (OC-6-11)-hexafluoroantimonate(1-) (9CI) (CA INDEX NAME)

CM 1

CRN 70084-23-0 CMF C19 H17 O S

CM 2

CRN 17111-95-4 CMF F6 Sb CCI CCS

RN 127820-38-6 CAPLUS

CN Sulfonium, tris(4-methylphenyl)-, trifluoromethanesulfonate (1:1) (CA INDEX NAME)

CM 1

CRN 47197-43-3 CMF C21 H21 S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 127820-39-7 CAPLUS

CN Sulfonium, tris(4-chlorophenyl)-, 1,1,1-trifluoromethanesulfonate (1:1) (CA INDEX NAME)

CM 1

CRN 125853-07-8 CMF C18 H12 C13 S

CRN 37181-39-8 CMF C F3 O3 S

CN

RN 127855-15-6 CAPLUS

Sulfonium, (4-methylphenyl)diphenyl-, (OC-6-11)-hexafluoroantimonate(1-) (9CI) (CA INDEX NAME)

CM 1

CRN 47045-31-8 CMF C19 H17 S

CM 2

CRN 17111-95-4 CMF F6 Sb CCI CCS

RN 127855-16-7 CAPLUS

CN Sulfonium, bis(4-methylphenyl)phenyl-, (OC-6-11)-hexafluoroantimonate(1-) (9CI) (CA INDEX NAME)

CM 1

CRN 70082-58-5 CMF C20 H19 S

CM 2

CRN 17111-95-4 CMF F6 Sb CCI CCS

RN 127855-18-9 CAPLUS

CN Sulfonium, bis(4-chlorophenyl)phenyl-, (OC-6-11)-hexafluoroantimonate(1-) (9CI) (CA INDEX NAME)

CM 1

CRN 127855-17-8 CMF C18 H13 C12 S

CRN 17111-95-4

CMF F6 Sb

RN 127855-20-3 CAPLUS

CN Sulfonium, bis(4-methoxyphenyl)phenyl-, (OC-6-11)-hexafluoroantimonate(1-) (9CI) (CA INDEX NAME)

CM 1

CRN 127855-19-0 CMF C20 H19 O2 S

CM 2

CRN 17111-95-4

CMF F6 Sb

CCI CCS

RN 127855-21-4 CAPLUS

CN Sulfonium, (4-fluorophenyl)diphenyl-, (OC-6-11)-hexafluoroantimonate(1-) (9CI) (CA INDEX NAME)

CM 1

CRN 70084-25-2 CMF C18 H14 F S

CM 2

CRN 17111-95-4 CMF F6 Sb CCI CCS

RN 127855-22-5 CAPLUS

CN Sulfonium, (4-bromophenyl)diphenyl-, (OC-6-11)-hexafluoroantimonate(1-) (9CI) (CA INDEX NAME)

CM 1

CRN 70244-60-9 CMF C18 H14 Br S

CRN 17111-95-4 CMF F6 Sb

CCI CCS

RN 127855-24-7 CAPLUS

CN Sulfonium, (4-benzoylphenyl)diphenyl-, (OC-6-11)-hexafluoroantimonate(1-) (9CI) (CA INDEX NAME)

CM 1

CRN 127855-23-6 CMF C25 H19 O S

CM 2

CRN 17111-95-4 CMF F6 Sb

CCI CCS

CN Sulfonium, tris(4-methylphenyl)-, bromide (1:1) (CA INDEX NAME)

• Br-

RN 125428-43-5 CAPLUS CN Sulfonium, tris(4-chlorophenyl)-, bromide (1:1) (CA INDEX NAME)

• Br-

L5 ANSWER 14 OF 18 CAPLUS COPYRIGHT 2008 ACS on STN

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10/576,299 07/06/2008

ACCESSION NUMBER:

1990:138734 CAPLUS

DOCUMENT NUMBER:

112:138734

ORIGINAL REFERENCE NO.:

112:23443a,23446a

TITLE:

Synthesis of triarylsulfonium salts

INVENTOR(S):

Dektar, John Louis; Hacker, Nigel Patrick International Business Machines Corp., USA

PATENT ASSIGNEE(S):

Eur. Pat. Appl., 5 pp.

SOURCE:

CODEN: EPXXDW

DOCUMENT TYPE:

Patent

LANGUAGE:

English

FAMILY ACC. NUM. COUNT:

1

PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE			
EP 327194	A1 .	19890809	EP 1989-300075	19890105			
EP 327194	B1	19920708					
R: DE, FR, GB							
JP 02001469	Α	19900105	JP 1988-316571	19881216			
JP 06015524	В	19940302					
US 4980492	A·	19901225	US 1989-317235	19890228			
PRIORITY APPLN. INFO.:			US 1988-152729 A	19880205			
AB The title compds. are prepared by the reaction of an aryl Grignard							
reagent with a diaryl sulfoxide using a solvent (mixture of aliphatic							

and aromatic hydrocarbons) followed by metathesis with ZMF6. (Z = metal or metal-like; M = As, P, Sb) in a nonaq. solvent. Ph3S+Br- (prepared from PhMgBr and Ph2SO) and NH4+PF6- were mixed in MeCN and stirred for 15 h to give 86% Ph3S+PF6-.

ΙT 3353-89-7P 3744-11-4P 125428-43-5P

RL: SPN (Synthetic preparation); PREP (Preparation)

(preparation and metathesis reaction of)

RN 3353-89-7 CAPLUS

CN Sulfonium, triphenyl-, bromide (1:1) (CA INDEX NAME)

Br⁻

RN 3744-11-4 CAPLUS

CN Sulfonium, tris(4-methylphenyl)-, bromide (1:1) (CA INDEX NAME)

• Br

RN 125428-43-5 CAPLUS CN Sulfonium, tris(4-chlorophenyl)-, bromide (1:1) (CA INDEX NAME)

● Br⁻

CM 2

RN 57840-38-7 CAPLUS
CN Sulfonium, triphenyl-, (OC-6-11)-hexafluoroantimonate(1-) (1:1) (CA INDEX NAME)

CM 1

CRN 18393-55-0 CMF C18 H15 S

CM 2

CRN 17111-95-4 CMF F6 Sb CCI CCS

RN 62770-64-3 CAPLUS
CN Sulfonium, tris(4-methylphenyl)-, (OC-6-11)-hexafluoroantimonate(1-) (9CI)
(CA INDEX NAME)

CM · 1

CRN 47197-43-3 CMF C21 H21 S

CRN 17111-95-4 CMF F6 Sb CCI CCS

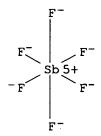
RN 125853-08-9 CAPLUS
CN Sulfonium, tris(4-chlorophenyl)-, (OC-6-11)-hexafluoroantimonate(1-) (9CI) (CA INDEX NAME)

CM 1

CRN 125853-07-8 CMF C18 H12 C13 S

CM 2

CRN 17111-95-4 CMF F6 Sb CCI CCS



L5 ANSWER 15 OF 18 CAPLUS COPYRIGHT 2008 ACS on STN

ACCESSION NUMBER: 1988:589923 CAPLUS

DOCUMENT NUMBER: 109:189923

ORIGINAL REFERENCE NO.: 109:31423a,31426a

TITLE: Deoxygenation of sulfoxides promoted by electrophilic

silicon reagents: preparation of aryl-substituted

sulfonium salts

AUTHOR(S): Miller, R. D.; Renaldo, A. F.; Ito, H.

CORPORATE SOURCE: Almaden Res. Cent., IBM Res. Div., San Jose, CA,

95120-6099, USA

SOURCE: Journal of Organic Chemistry (1988), 53(23), 5571-3

CODEN: JOCEAH; ISSN: 0022-3263

DOCUMENT TYPE: Journal LANGUAGE: English

OTHER SOURCE(S): CASREACT 109:189923

AB A new one-step synthesis of triaryl and alkylarylsulfonium salts has been developed. Treatment of diaryl sulfoxides with Grignard reagents, in the presence of alkylsilicon reagents, gave the corresponding sulfonium salts in moderate yields. The reaction, performed under mild conditions, can tolerate a variety of functional groups. Significantly, the unsym. sulfonium salts were isolated without the complication of

ligand exchange. The scope of this methodol. as well as possible

synthetic utility is discussed. IT 3353-89-7P 66003-78-9P 81416-37-7P

111281-12-0P 116808-64-1P 116808-66-3P 116808-67-4P 116808-69-6P 116808-75-4P

RL: SPN (Synthetic preparation); PREP (Preparation)

(preparation of)

RN 3353-89-7 CAPLUS

CN Sulfonium, triphenyl-, bromide (1:1) (CA INDEX NAME)

● Br

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10/576,299 07/06/2008
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RN 66003-78-9 CAPLUS
CN Sulfonium, triphenyl-, 1,1,1-trifluoromethanesulfonate (1:1) (CA INDEX NAME)

CM 1

CRN 37181-39-8 CMF C F3 O3 S

CM 2

CRN 18393-55-0 CMF C18 H15 S

RN 81416-37-7 CAPLUS
CN Sulfonium, (4-methylphenyl)diphenyl-, 1,1,1-trifluoromethanesulfonate (1:1) (CA INDEX NAME)

CM 1

CRN 47045-31-8 CMF C19 H17 S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

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RN 111281-12-0 CAPLUS
CN Sulfonium, diphenyl[4-(phenylthio)phenyl]-, 1,1,1 trifluoromethanesulfonate (1:1) (CA INDEX NAME)

CM 1

CRN 47480-44-4 CMF C24 H19 S2

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 116808-64-1 CAPLUS CN Sulfonium, (4-ethenylphenyl)diphenyl-, bromide (9CI) (CA INDEX NAME)

● Br⁻

RN 116808-66-3 CAPLUS

CN Sulfonium, diphenyl[4-(trifluoromethyl)phenyl]-, salt with trifluoromethanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 116808-65-2 CMF C19 H14 F3 S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 116808-67-4 CAPLUS

CN Sulfonium, (4-methoxyphenyl)diphenyl-, 1,1,1-trifluoromethanesulfonate (1:1) (CA INDEX NAME)

CM 1

CRN 70084-23-0 CMF C19 H17 O S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 116808-69-6 CAPLUS
CN Sulfonium, 1-naphthalenyldiphenyl-, salt with trifluoromethanesulfonic
 acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 116808-68-5 CMF C22 H17 S

CM 2

CRN 37181-39-8 CMF C F3 O3 S

RN 116808-75-4 CAPLUS

CN Sulfonium, (4-ethenylphenyl)diphenyl-, salt with trifluoromethanesulfonic acid (1:1) (9CI) (CA INDEX NAME)

CM 1

CRN 116808-74-3 CMF C20 H17 S

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CRN 37181-39-8 CMF C F3 O3 S

L5 ANSWER 16 OF 18 CAPLUS COPYRIGHT 2008 ACS on STN

ACCESSION NUMBER: 1988:528785 CAPLUS

DOCUMENT NUMBER: 109:128785

ORIGINAL REFERENCE NO.: 109:21449a,21452a

TITLE: Occurrence of ligand coupling in the reactions of

various sulfoxides with Grignard reagents

AUTHOR(S): Kawai, Tsutomu; Kodera, Yoichi; Furukawa, Naomichi;

Oae, Shigeru; Ishida, Masahiro; Takeda, Takashi;

Wakabayashi, Shoji

CORPORATE SOURCE: Dep. Chem., Univ. Tsukuba, Sakura, 305, Japan

SOURCE: Phosphorus and Sulfur and the Related Elements (1987),

34 (3-4), 139-48

CODEN: PREEDF; ISSN: 0308-664X

DOCUMENT TYPE: Journal

LANGUAGE: English

OTHER SOURCE(S): CASREACT 109:128785

GI ·

$$S(0)$$
 R1 $N = N$ $N = N$

AB Reaction of RS(O)CH2Ph (I; R = 4-pyridyl) with PhMgBr gave 60% of the ligand coupling product 4-benzylpyridine. Similarly, I (R = 2-pyridyl) was treated with MeMgBr, EtMgBr, or PhMgBr to give 83-98% 2-benzylpyridine. In contrast, I (R = 3-pyridyl) and PhMgBr gave the ligand exchange products PhS(O)CH2Ph and PhS(O)Ph in 15 and 48% yield, resp. Reaction of 2-pyridyl sulfoxides II (R1 = Me, Et, Ph) with EtMgBr gave bipyridine III. A similar reaction of II (R1 = Me) with PhCH2MgCl gave 79% 2-benzylpyridine. The ease of coupling seems to be associated with the electronegativity of the coupling C atom of the ligand as shown by a comparison of the 13C NMR chemical shifts.

IT 3353-89-7

RL: RCT (Reactant); RACT (Reactant or reagent)
 (carbon-13 NMR spectral characteristics of)

RN 3353-89-7 CAPLUS

CN Sulfonium, triphenyl-, bromide (1:1) (CA INDEX NAME)

● Br¯

q.

L5 ANSWER 17 OF 18 CAPLUS COPYRIGHT 2008 ACS on STN

ACCESSION NUMBER: 1952:8508 CAPLUS

DOCUMENT NUMBER: 46:8508

ORIGINAL REFERENCE NO.: 46:1482e-i,1483a-b

TITLE: Preparation of triarylsulfonium halides by the action

of aryl Grignard reagents on diphenyl

sulfoxide

AUTHOR(S): Wildi, Bernard S.; Taylor, Sheldon W.; Potratz, H. A.

CORPORATE SOURCE: Washington Univ., St. Louis, MO

SOURCE: Journal of the American Chemical Society (1951), 73,

1965-7

CODEN: JACSAT; ISSN: 0002-7863

DOCUMENT TYPE: Journal LANGUAGE: Unavailable

AB To PhMgBr from 41.8 g. distilled PhBr, 300 ml. dry ether, and 6 g. Mg was added 300 ml. C6H6, the ether removed, 10 g. Ph2SO (I) in 100 ml. C6H6 added, the mixture refluxed 23 hrs. under N, cooled to 0°, hydrolyzed with 21 ml. HBr (d. 1.38) in 21 ml. H2O, the C6H6 layer extracted with four 80-ml. portions of aqueous 5% HBr, the combined exts. and the aqueous layer from

the hydrolysis extracted with six 100-ml. portions of CHCl3, and the CHCl3 removed from the combined exts. to give 8.4 g. (49.4%) colorless Ph3SBr (II), m. 285-6° (crystallized twice from CHCl3-Me2CO), readily soluble in H2O, CHCl3, EtOH, and C5H5N and insol. in ether, Me2CO, or C6H6; AgBr precipitated when the aqueous solution was treated with AgNO3. The C6H6 solution from the

hydrolysis, dried over anhydrous Na2SO4 and evaporated to remove the C6H6, gave an amber liquid: vacuum distillation yielded 8.0 g. PhBr, b25 54°, and a fraction b3 108-48° which partially crystallized at 0° to yield 1.18 g. I, m. 70° (from petr. ether). To 1.725 g. II in 25 ml. H2O was added 0.845 g. AgNO3 in 25 ml. H2O, the AgBr removed, and the filtrate evaporated to dryness to give 0.268 g. colorless crystals of Ph3SNO3, m. 227-7.5° (from Me2COCHCl3, 5:1 by volume). With 50 ml. C6H6 and 50 ml. ether, PhLi was made from 1.94 g. Li and 22.2 g. PhBr, 15 g. I in 50 ml. C6H6 added during 3 hrs., and the mixture refluxed 24 hrs., then decomposed with dilute HBr as above; evaporation of the CHCl3 exts. gave 0.05

II, m. 284-5° (from Me2COCHCl3, 5:1, by addition of ether). II (1 g.) in 100 ml. H2O was treated with 1 equivalent of moist Ag2O, stirred 3 days, at room temperature in the dark, and filtered (the filtrate was strongly basic to litmus); evaporation gave a strongly basic oil which lost basicity on standing at room temperature to yield an amorphous gum. Ph2(p-MeC6H4)SBr was made similarly from the Grignard reagent from 77.8 g. p-MeC6H4Br and 7.74 g. Mg refluxed with 10 g. Ph2SO 24 hrs. at 70°; hydrolysis with dilute aqueous HBr gave 6.01 g. (34%) sulfonium bromide, m. 224-5° (from Me2CO-CHCl3, 5:1 by volume), soluble in CHCl3, H2O, EtOH, and C5H5N but insol. in Me2CO, C6H6, and ether. Similarly the Grignard reagent from 77.8 g. m-MeC6H4Br and 77.4 g. Mg treated with 10 q. I 48

hrs. at 70° gave 41.2 g. (23.4%) (from Me2CO-CHCl3, 5:1, by addition of ether) Ph2(m-MeC6H4)SBr, m. 209-23°, soluble in H2O, CHCl3, EtOH, C5H5N, and insol. in ether, C6H6, or Me2CO. The Grignard reagent from 44.0 g. 2,4-Me2C6H3Br and 6.1 g. Mg treated with 7.2 g. I 75 hrs. at 70° gave 12.1% Ph2(2,4-Me2C6H3)SBr, m. 239-9.5° (recrystn. as above), soluble in H2O, CHCl3, EtOH, and C5H5N but insol in Me2CO, C6H6, or ether. All of the sulfonium compds. prepared gave a blue precipitate in water with the cobaltous ammonium thiocyanate complex used as a qual. test for sulfonium compds. Absorption spectra measurements made in 95% EtOH with a Beckman spectrophotometer, model D. U., are shown on a graph.

IT 4189-82-6P, Sulfonium, diphenyl-p-tolyl-, bromide 31688-57-0P, Sulfonium, diphenyl-2,4-xylyl-, bromide 347841-66-1P, Sulfonium, diphenyl-m-tolyl-, bromide RL: PREP (Preparation)

(preparation of)

RN 4189-82-6 CAPLUS

CN Sulfonium, (4-methylphenyl)diphenyl-, bromide (9CI) (CA INDEX NAME)

Br⁻

RN 31688-57-0 CAPLUS CN Sulfonium, diphenyl-2,4-xylyl-, bromide (8CI) (CA INDEX NAME)

● Br-

RN 347841-66-1 CAPLUS CN Sulfonium, (3-methylphenyl)diphenyl-, bromide (1:1) (CA INDEX NAME)

● Br⁻

IT 18393-55-0, Sulfonium, triphenyl-(salts)

RN 18393-55-0 CAPLUS

CN Sulfonium, triphenyl- (CA INDEX NAME)

L5 ANSWER 18 OF 18 CAPLUS COPYRIGHT 2008 ACS on STN

ACCESSION NUMBER: 1935:1120 CAPLUS

DOCUMENT NUMBER: 29:1120

ORIGINAL REFERENCE NO.: 29:142h-i,143a

TITLE: The phenyl tolyl and ditolyl sulfoxides

AUTHOR(S): Courtot, Charles; Frenkiel, Joseph SOURCE: Compt. rend. (1934), 199, 557-9

DOCUMENT TYPE: Journal LANGUAGE: Unavailable

AB cf. C. A. 26, 3784; 28, 1028.3. By condensation of the corresponding sulfonyl chlorides of PhMe with C6H6 in the presence of AlCl3 the following compds. were obtained: o-tolyl phenyl sulfoxide m. 42°, bll 220° m-sulfoxide bl2 215°. Its sulfone m. 109°. Condensation of o-MeC6H4SO2Cl in the same manner

sulfone m. 109°. Condensation of o-MeC6H4SO2Cl in the same manner yields o,p'-ditolyl sulfoxide, m. 90°, b9 210deg;. Its sulfone m. 60°. In the same reaction there is also obtained o,p',p''-tritolyl-thionium chloride, m. 128°. o,m'-Ditolyl sulfide on oxidation yields o,m'-ditolyl sulfoxide (I), b9 213°. Its sulfone m. 82°. m,p'-Ditolyl sulfoxide, obtained like I, m. 72°. o,o'-Ditolyl sulfoxide (II), synthesized by the Grignard method, m. 121° yield 26%. m,m'-Ditolyl sulfoxide, obtained like II, b16 215°. No exptl. details are given.

IT 856059-85-3P, Sulfonium, o-tolyldi-p-tolyl-, chloride RL: PREP (Preparation) (preparation of)

RN 856059-85-3 CAPLUS

CN Sulfonium, (2-methylphenyl)bis(4-methylphenyl)-, chloride (1:1) (CA INDEX NAME)

---Logging off of STN---

Executing the logoff script...

=> LOG Y

COST IN U.S. DOLLARS	SINCE FILE	TOTAL
	ENTRY	SESSION
FULL ESTIMATED COST	103.78	282.35
DISCOUNT AMOUNTS (FOR QUALIFYING ACCOUNTS)	SINCE FILE	TOTAL
	ENTRY	SESSION
CA SUBSCRIBER PRICE	-14.40	-14.40

STN INTERNATIONAL LOGOFF AT 09:57:36 ON 06 JUL 2008